TAAB Grids offer unprecedented transmission without loss of support, have clean smooth bars with **specified** aperture sizes and are manufactured to very fine tolerances. Extremely high quality grids packed 100 grids per vial.

100 Micro	n	50 Mit	Cron		25 Micro	on		HT300
Lines/inch	GT001/C = 100	Micron Copper	Material		um			Hole/Bar
Mesh	Style	Cat. No.	Copper	Pitch	Bar Width	Hole Width	Transmission	Ratio
203	100 MICRON	GT001/C	✓	125	25	100	64%	4:1
363	50 MICRON	GT002/C	✓	70	20	50	51%	2.5:1
604	25 MICRON	GT003/C	✓	42	17	25	35%	1.5:1
300	HT300	GT004/C	$\checkmark$	84	7.5	76.5	83%	10.2:1

### **Maxtaform & Embra Grids**

See also page 1.23 for Maxtaform New Value Range

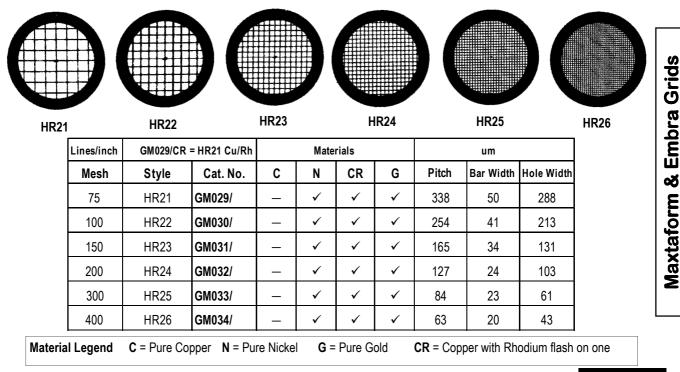
## Copper, Copper/Rhodium, Nickel and Maxtaform Gold grids are packed 100 grids per vial, Embra Gold grids and all other materials are in quantities of 25 grids per vial.

Apart from grids coated on one side with rhodium, all grids in copper, nickel and gold are matt on one side, bright on the other side.

All grids are approximately 25 micron thickness.

#### Square Mesh - High Grade Range 3.05mm - Maxtaform

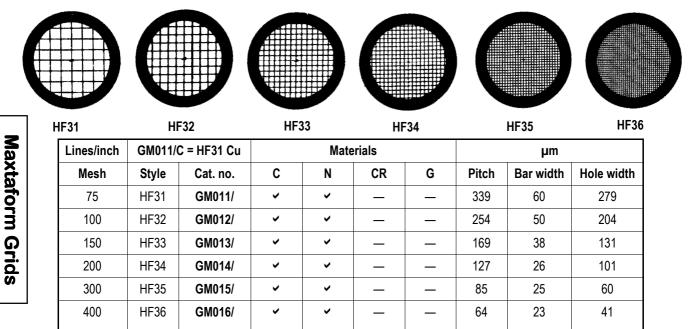
Special attention should be drawn to this High Grade range of grids with the feature of reduced bar widths. These grids are available in Copper with one surface coated with inert Rhodium, noted for it's stability over long periods of time. These extra high quality grids eliminate tarnishing and give positive identification of one surface. The high quality range is completed with grids in Gold and Nickel.



1.1

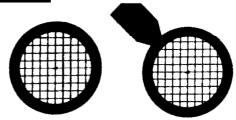
#### Square Mesh - Economy Range 3.05mm - Maxtaform

The economy range of EM grids was designed to provide good quality square mesh grids at a very competitive price. The continual high demand for these grids means that it is still possible to manufacture at a low price without losing the inherent quality of Maxtaform grids.



#### Square Mesh - Plain & with Handles 3.05mm - Embra

Embra & Maxtaform grids are now manufactured by the same company



Copper and Nickel grids are packed 100 grids per vial, all other materials are in quantities of 25 grids/vial

Lines/inch	GM001/C	= 1G75 Cu			Ма	teri	als					μn	n Sin	nilar to
Mesh	Style	Cat. no.	С	Ν	G	М	S	Т	Α	Pitch	Bar width	Hole width	Maxtaform	Handle/Tab
75	1G75	GE001/	~	~	~	>	~	~	~	339	55	284	HF31	_
75	3HG75	GE002/	~	~	~	~	~	~	~	339	55	284	HF32	>
100	!G100	GE003/	~	~	~	~	~	~	~	254	50	204	HF32	_
100	3HG100	GE004/	~	~	_	_	_	_	_	254	50	204	HF33	>
150	1G150	GE005/	~	~	~	~	~	~	~	169	44	125	HF33	_
150	3HG150	GE006/	~	~	~	—	_	—	_	169	44	125	HF34	>
200	1G200	GE007/	~	~	~	~	~	~	~	127	37	90	HF34	_
200	3HG200	GE008/	~	~	~	~	~	~	—	127	37	90	HF35	>
300	1G300	GE009/	~	~	~	~	~	~	_	85	31	54	HF35	_
300	3HG300	GE010/	~	~	~	~	~	~	_	85	31	54		~

Material Legend C =

C = Pure CopperN = Pure NickelG = Pure GoldS = Stainless SteelT = TungstenA= Aluminium

**CR** = Copper with Rhodium flash on one face **M**= Molybdenum

**Embra Grids** 

#### Slotted & Hole Range 3.05mm - Maxtaform





0

HF51



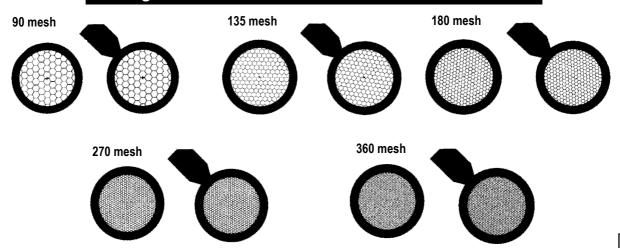
HF47



HF48

Lines/inch	GM025N =	HF29 Nickel		Mate	erials		μm		
Mesh	Style	Cat. no.	С	Ν	CR	G	Pitch	Bar width	Hole width
—	HF49	GM025/	~	~	—	_	—	—	2000 x 1000
—	HF50	GM026/	~	~	_	_	_	—	1500 x 200
—	HF51	GM027/	~	~	_	_	_	—	500 x 200
-	HF57	GM023/	~	~	_	_	_	—	1000
_	HF48	GM024/	~	>	_	_	_	_	6000

Hexagonal Mesh - Plain & with Handles 3.05mm - Embra



Lines/inch	GM015/C	= 8G90 Cu								μι	m	
Mesh	Style	Cat. no.	С	Ν	G	М	S	Т	Pitch	Bar width	Hole width	Handle/Tab
90	8G90	GE015/	>	>	~	—	—	—	272	48	_	_
90	8HG90	GE016/	~	~	—	—	_	—	272	48	_	>
135	8G135	GE017/	~	~	~	—	_	—	186	36	_	_
135	8HG135	GE018/	~	_	—	_	_	_	186	36	_	>
180	8G180	GE019/	~	~	~	—	_	—	138	28	_	_
180	8HG180	GE020/	~	~	~	—	_	—	138	28	_	>
270	8G270	GE021/	~	~	~	—	—	—	90	24	_	_
270	8HG270	GE022/	~	~	~	—	—	—	90	24	_	~
360	8G360	GE023/	~	~	~	_	_	—	67	26	_	_
360	8HG360	GE024/	~	~	~	_	_	—	67	26	_	~

 Material Legend
 C = Pure Copper
 N = Pure Nickel

 M= Molybdenum
 S=Stainless Ste

N = Pure NickelG = Pure GoldS=Stainless SteelT= Tungsten

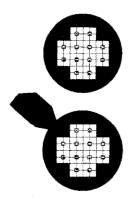
Pure Gold CR = Co unasten

 $\ensuremath{\text{CR}}$  = Copper with Rhodium flash on one face

**Embra Grids** 

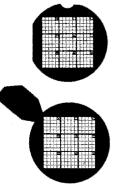
1

#### Special Patterns - Plain & with Handles 3.05mm - Embra



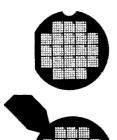
Reference identification of each of twelve grid squares

Lines/inch	GE025/C =	= 7FG100 Cu			Mate	rials					μm	
Mesh	Style	Cat. no.	С	Ν	G	М	S	Т	Pitch	Bar width	Hole width	Handle/ Tab
100	7FG100	GE025/	~	~	_	I	_	I	250		_	_
100	7HFG100	GE026/	~	•	—		_		250		—	~



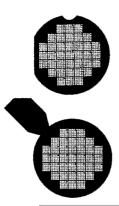
Reference identification of each of nine grid squares

Lines/inch	GE027/C =	= 7FG200 Cu			Mate	rials					μm	
Mesh	Style	Cat. no.	С	Ν	G	М	S	Т	Pitch	Bar width	Hole width	Handle/ Tab
200	7FG200	GE027/	>	>	~	—	l	1	125	_	_	
200	7HFG200	GE028/	>	>	~	—			125	_	—	~



Reference identification of each of twenry one grid squares

Lines/inch	GE029/C :	= 7FG300 Cu			Mate	rials					μm	
Mesh	Style	Cat. no.	С	N	G	М	S	T	Pitch	Bar width	Hole width	Handle/ Tab
300	7FG300	GE029/	~	~	~	—	_	_	83		_	_
300	7HFG300	GE030/	~	~	~	—	_	_	83	-	_	~



Reference identification of each of thirty seven squares

**C** = Pure Copper **N** = Pure Nickel

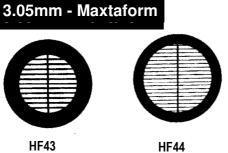
**S** = Stainless steel **T** = Tungsten

Lines/inch	GE031/C =	= 7FG400 Cu			Mate	rials					μm	
Mesh	Style	Cat. no.	С	Ν	G	М	S	Т	Pitch	Bar width	Hole width	Handle/ Tab
400	7FG400	GE031/	>	~	~	—	l	_	62		_	_
400	7HFG400	GE032/	>	•	~	—		—	62		_	>

**CR** = Copper with Rhodium flash on one face

Material Legend

**G** = Pure Gold







HF46

Parallel with single bar crossed at 90° through the centre of the grid

Lines/inch	n GM021/C	= (HF45 Cu)	Mater	ials			μm		
Mesh	Style	Cat. no.	С	Ν	CR	G	Pitch	Bar width	Hole width
150	HF45	GM019/	~	~	-	-	165	34	131
200	HF46	GM020/	~	~	-	-	127	24	103

#### Parallel

**HF43** 

Lines/incl	h GM021/C	(= HF45 Cu)	Mate	rials			μm		
Mesh	Style	Cat. no.	С	Ν	CR	G	Pitch	Bar width	Hole width
150	HF45	GM021/	~	~	-	-	165	34	131
200	HF46	GM022/	~	~	-	-	127	24	103

**Co-ordinate Grids** 

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	E		
		-	
	-		

**HR27** 

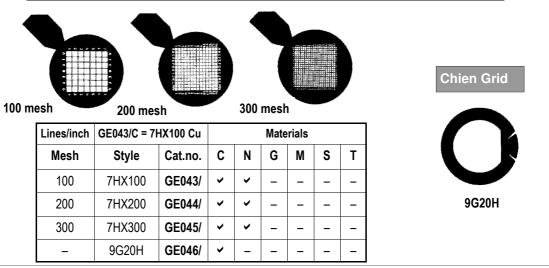


**HF41** 



**HF42** 

Lines/inch	n GM021/C	= (HF45 Cu)	Mater	ials			μm		
Mesh	Style	Cat. no.	С	Ν	CR	G	Pitch	Bar width	Hole width
300-75	HR27	GM035/	_	~	~	~	338x84	50 & 83	288x61
75-300	HF41	GM017/	~	~	_	_	338x84	60 & 25	278x59
100-400	HF44	GM018/	~	~	_	-	254x63	50 & 23	204x40

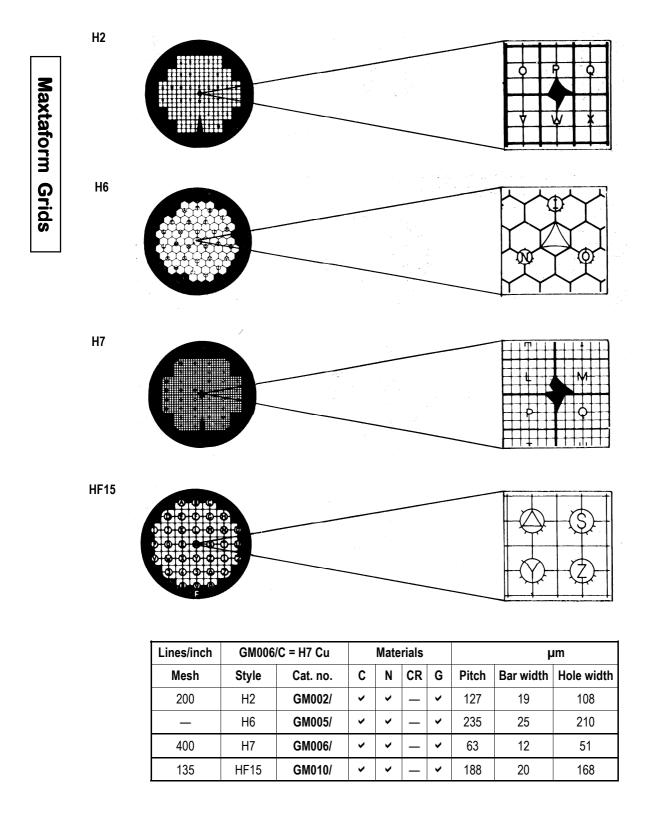


Material Legend C = Pure Copper N = Pure Nickel G = Pure Gold **CR** = Copper with Rhodium flash on one face S = Stainless Steel T = Tungsten

**Embra Grids** 

#### Reference Range 3.05mm - Maxtaform

It was Graticules who introduced reference patterns to optical microscopy and carried the advantage into electron microscopy by being the first to make reference grids. The four patterns illustrated will provide the microscopist with a wide choice to suit their particular needs.



**Material Legend C** = Pure Copper **N** = Pure Nickel

**G** = Pure Gold **CR** = Copper w

**CR** = Copper with Rhodium flash on one face

#### Specialist Range 3.05mm - Maxtaform **HF14** H1 H9 HF52 H4 H5 Lines/inch GM001/C = H1 Cu Materials μm Mesh Style Cat.no. С Ν CR G Pitch Bar width Hole width 200 H1 GM001/ 127 15 112 $\checkmark$ V \_ $\checkmark$ 400 H4 GM003/ ~ V \_ ~ 63 12 51 H5 GM004/ 235 25 210 ~ ~ ~ \_ \_ 25 483 50 H9 GM007/ ~ V • 508 \_ HF14 127 22 105 200 GM009/ 4 V -V

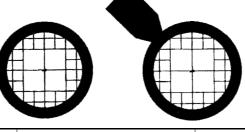
### Freeze Fracture Grid 3.05mm - Embra

\_

\_

254/127

47/25



For 200 mesh Freeze Fracture grid -Please see HF14 above.

72

<b>Franza</b>
⊢reeze

100

HF52

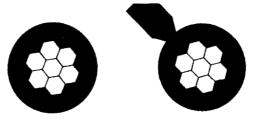
GM028/

V

V

Lines/inc	h GE033/C =	5G75FF Cu	Mate	rials					μm			
Mesh	Style	Cat. no.	C	N	G	М	S	Т	Pitch	Bar width	Hole width	Handle/ Tab
75	5G75FF	GE033/	~	~	~	-	-	-	339	55	284	-
75	5HG75FF	GE034/	~	~	-	-	-	-	339	55	284	~

#### 7 Hexagon Grid 3.05mm - Embra

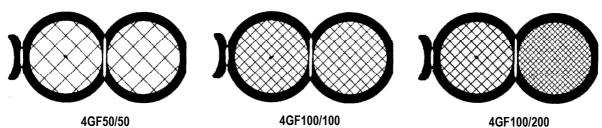


Lines/incl	h GE013/C =	= 1G7Hex Cu	Mate	rials					μm			
Mesh	Style	Cat. no.	C	N	G	М	S	Т	Pitch	Bar width	Hole width	Handle/ Tab
-	1G7Hex	GE013/	~	>	>	-	-	-	-	-	-	-
-	3G7Hex	GE014/	~	>	I	-	-	-	-	-	-	~
Material Le	egend C	= Pure Copper	• N = I	Pure N	lickel	G =	= Pure	Gold	<b>CR</b> = C	opper with	Rhodium fla	sh on one

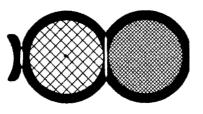
Maxtaform Grids

**Embra Grids** 

#### Folding Grids 3.05mm - Embra



4GF50/50

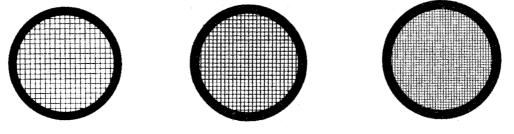


4GF100/300

4GF100/400

Lines/inch	GGEO31/C =			Mate	rials			μm			
Mesh	Style	Cat. no.	С	Ν	G	М	S	Т	Pitch	Bar width	Hole width
50-50	4GF50/50	GE035/	~	~	~	—	_	_	508-508	83-83	425-425
100-100	4GF100/100	GE036/	~	~	~	~	~	~	254-254	65-65	189-189
100-200	4GF100/200	GE037/	>	~	~	•	~	~	254-127	65-37	189-90
100-300	4GF100/300	GE038/	~	~	~	_	~	~	254-85	65-28	189-57
100-400	4GF100/400	GE039/	~	~	—	—	—	—	254-64	65-26	189-38

Embra- Tissue Processing Screen - Diameter 3.8mm



Lines/inch	GGEO31/C	= 4GF50/50 Cu		Mate	rials			μm		Transmission
Mesh	Style	Cat. no.	С	Ν	CR	G	Pitch	Bar width	Hole width	%
150	6G150	GE040/	~	~	—	_	170	44	126	55
200	6G200	GE041/	~	~	—	—	127	37	90	50
300	6G300	GE042/	~	~	_	—	85	28	57	45

Please note that these screens are 3.8mm diameter

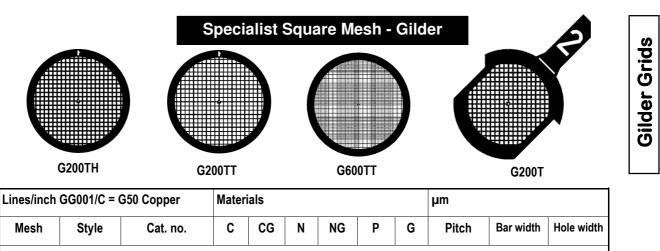
Material Legend C = Pure Copper N = Pure Nickel S=Stainless Steel

G = Pure Gold T= Tungsten M= Molybdenum

**CR** = Copper with Rhodium flash on one face

$ \begin{array}{ c c c c c c c c c c c c c c c c c c c$	Gilder (	Grids		Sta	anda	rd S	qua	re N	lesh	- Gilde	r		
Lines/inch         GG001/C = G50 Cu         Materials $\mu$ m           Mesh         Style         Cat.no.         C         CG         N         NG         P         G         Pitch         Bar width         Hole width           50         G50         GG001/ $\checkmark$ $\checkmark$ $\checkmark$ $\checkmark$ $500$ 800         420           75         G75         GG002/ $\checkmark$ $\checkmark$ $\checkmark$ $\checkmark$ $3400$ 555         285           100         G100         GG003/ $\checkmark$ $\checkmark$ $\checkmark$ $\checkmark$ $250$ 45         205           150         G150         GG004/ $\checkmark$ $\checkmark$ $\checkmark$ $\checkmark$ $165$ 400         125           175         G175         GG070/ $\checkmark$ $\checkmark$ $\checkmark$ $\checkmark$ $\checkmark$ $145$ 37         108													
Mesh         Style         Cat.no.         C         CG         N         NG         P         G         Pitch         Bar width         Hole width           50         G50         GG001/         ~         ~         ~         ~         ~         50         80         420           75         G75         GG002/         ~         ~         ~         ~         ~         340         555         285           100         G100         GG003/         ~         ~         ~         ~         ~         250         45         205           150         G150         GG004/         ~         ~         ~         ~         ~         250         45         205           175         G175         GG070/         ~         ~         ~         ~         ~         165         40         125           175         G175         GG070/         ~         ~         ~         ~         ~         145         37         108	G50	G75	5		G100			G150	)	G1	75	G200	G250
50         G50         GG001/         ~         ~         ~         ~         ~         50         80         420           75         G75         GG002/         ~         ~         ~         ~         ~         340         55         285           100         G100         GG003/         ~         ~         ~         ~         ~         250         45         205           150         G150         GG004/         ~         ~         ~         ~         ~         165         40         125           175         G175         GG070/         ~         ~         ~         ~         ~         145         37         108	nes/inch	GG001/C = G5	i0 Cu			Mate	rials				μm		
75       G75       GG002/       ~       ~       ~       ~       ~       340       55       285         100       G100       GG003/       ~       ~       ~       ~       ~       340       55       285         100       G100       GG003/       ~       ~       ~       ~       ~       250       45       205         150       G150       GG004/       ~       ~       ~       ~       165       40       125         175       G175       GG070/       ~       ~       ~       ~       145       37       108	Mesh	Style C	Cat.no.	C	CG	Ν	NG	Р	G	Pitch	Bar width	Hole width	
100       G100       GG003/       ~       ~       ~       ~       ~       ~       250       45       205         150       G150       GG004/       ~       ~       ~       ~       ~       165       40       125         175       G175       GG070/       ~       ~       ~       ~       ~       145       37       108	50	G50 <b>G</b>	GG001/	~	~	~	~	~	~	500	80	420	
150       G150       GG004/       ~       ~       ~       ~       ~       165       40       125         175       G175       GG070/       ~       ~       ~       ~       ~       145       37       108	75	G75 <b>G</b>	GG002/	~	~	~	~	~	~	340	55	285	
175 G175 <b>GG070/</b> • • • • • • 145 37 108	100	G100 <b>G</b>	GG003/	~	~	~	~	~	~	250	45	205	
	150	G150 G	GG004/	~	~	~	~	~	~	165	40	125	G300
200 G200 <b>GG005</b> / • • • • • • 125 35 90	175	G175 <b>G</b>	GG070/	~	~	~	~	~	~	145	37	108	
	200	G200 G	GG005/	~	~	~	~	~	~	125	35	90	
250 G250 <b>GG071</b> / <b>~ ~ ~ ~ ~ 1</b> 00 30 70	250	G250 G	GG071/	~	~	~	~	~	~	100	30	70	
300 G300 <b>GG007</b> / • • • • • • 83 25 58	300	G300 G	GG007/	~	~	~	~	~	~	83	25	58	

G200 & G100 grids now available in Molybdenum GG005/M (200)



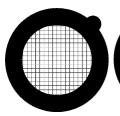
A thicken	ed version o	of the standard G2	<b>00</b> with	asymet	ric cen	tre and a	a mark i	n the ri	m for precise	orientation	in the TEM
200	G200TH	GG046/	~	~	~	~	~	~	125	40	85
			Thi	ck-Thir	bar s	quare m	esh				
200	G200TT	GG046/	~	~	~	~	~	~	125	35-25	95
600	G600TT	GG009/	~	~	~	~	~	~	42	16-10	30
Handle g		le has been design int of attachment to									etal at the
200	G200TT	GG038/	~	~	~	~	~	~	125	40	85

Material Legend **C** = Pure Copper **N** = Pure Nickel G = Pure Gold P = Copper with Palladium flash on one face CG = Copper with pure Gold flash on one side NG = Nickel with pure Gold flash on one side

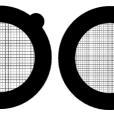
1

Fine Bar Square Mesh - Gilder

### **Gilder Grids**



G200HS



G300HS



G400HS

**Double/Folding Grids - Gilder** 

G600HS

G1000HS

G1500HS



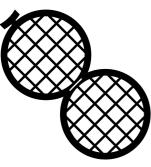
G2000HS



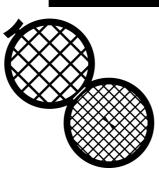
Bar width Hole width NG Ρ Pitch Mesh Style Cat.no. С CG G Ν 200 G200HS GG018/ V V V V 125 12 113 \_ \_ 300 G300HS GG020/ V V V V 83 10 73 \_ \_ ~ 8 54 400 G400HS GG022/ V  $\checkmark$ V \_ V 62 600 G600HS GG069/ V V V V V 42 5 37 \_ 1000 G1000HS GG039/ 25 6 19 V V V 4 \_ V 1500 G1500HS GG062/ ~ ~ ~ ~ V 16.5 5 11.5 \_ 2000 G2000HS GG063/ V V V V V 12.5 5 7.5 \_ V 200-250 GVHS GG025/ ~ ~ V \_ ~ 125-62 10-10 115-52 150-300 165-83 10-10 115-73

The handle has been designed for ease of handling and is eaily removed. The thickness of metal at the point of attachment of the handle to the rim is reduced to allow the handle to be bent up to 90°

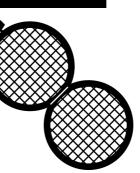
**GVHS** 



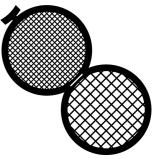
GD50/50



#### GD50/100



GD100/100



GD100/200

Used mostly in metallurgical applications for supporting	Lines/inch	GG034/C= GE	050/50 Cu			Mate	erials			μm			
applications for supporting thin metal foils. The grids	Mesh	Style	Cat.no.	С	CG	Ν	NG	Р	G	Pitch	Bar width	Hole width	
have a curved securing tab	50-50	GD50/50	GG034/	~	~	~	~	~	~	500-500	70-70	430-430	
which folds to the curvature of the 'sandwiched' grid.	50-100	GD50/100	GG035/	~	~	~	~	~	~	500-250	70-55	430-195	
	100-100	GD100/100	GG036/	~	~	~	~	~	~	250-250	50-50	200-200	
	100-200	GD100/200	GG037/	•	~	~	~	~	~	250-125	200-85	200-85	

Material Legend: C = Pure Copper

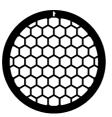
N = Pure Nickel **G** = Pure Gold **CG** = Copper with pure Gold flash on one side

**P** = Copper with Palladium flash on one face NG = Nickel with pure Gold flash on one side



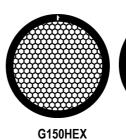
#### **Standard Hexagonal Mesh - Gilder**

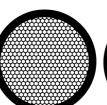




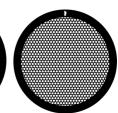
G50HEX

G75HEX





G200HEX



G300HEX

Lines/inch	GG057/N = G	50 Hex Nickel			Mate	rials			h	ım
Mesh	Style	Cat.no.	С	CG	Ν	NG	Ρ	G	Pitch	Bar width
50	G50HEX	GG057/	~	~	>	~	~	~	500	70
75	G75HEX	GG058/	~	~	>	~	~	~	340	50
100	G100HEX	GG016/	~	~	>	~	~	~	250	35
150	G150HEX	GG059/	~	~	>	~	~	~	165	35
200	G200HEX	GG017/	~	~	>	~	~	~	125	25
300	G300HEX	GG060/	~	~	>	~	~	~	83	25
400	G400HEX	GG061/	~	~	>	~	~	~	62	25

G100HEX

G400HEX

#### Fine Bar Hexagonal Mesh - Gilder



G300HH

G400HH



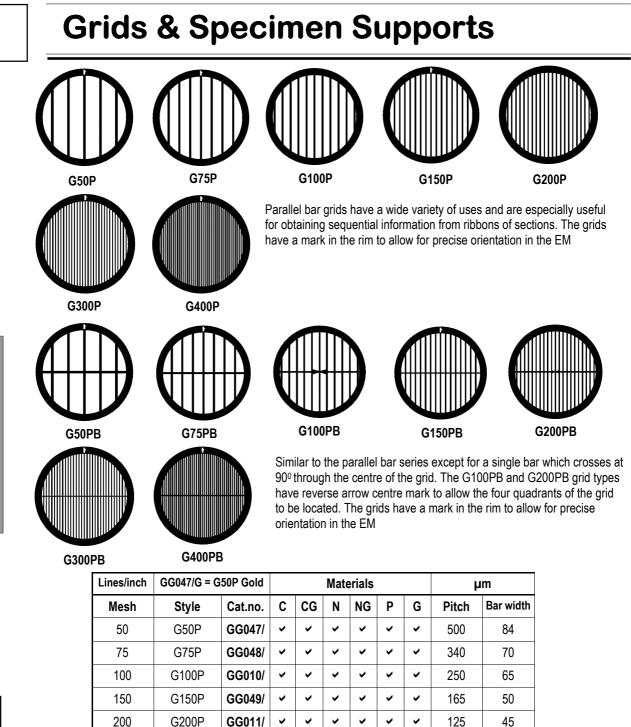


G600HHS

Lines/inch	Lines/inch GG057/N = G50 Hex Nickel				Mate		μm			
Mesh	Style	Cat.no.	С	CG	N	NG	Р	G	Pitch	Bar width
200	G200HH	GG019/	~	_	~	>	_	~	125	12
300	G300HH	GG021/	~	_	~	~	_	~	83	10
460	G400HH	GG023/	~	_	~	~	_	~	57	8
698	G600HH	GG024/	~	_	~	>	_	~	37	8
600	G600HHS	GG072/	~	~	~	~	—	~	42	5
600	G600HSS	GG069/	~	_	~	~	_	~	42	5

Material Legend C = Pure Copper N = Pure Nickel **G** = Pure Gold **P** = Copper with Palladium flash on one face CG = Copper with pure Gold flash on one side NG = Nickel with pure Gold flash on one side





400

50

75

100

150

200

300

400

G300P

G400P

G50PB

G75PB

G100PB

G150PB

G200PB

G300PB

G400PB

GG050/

GG051/

GG052/

GG053/

GG012/

GG054/

GG013/

GG055/

GG056/

V

V

Parallel with cross bar at 90° through the centre of the grid

V

v | v | v

v v v

~ ~ ~

V

V

~ ~

~

V

V

V

V

V

V

v

V

V

V

V

~

V

V

V

V

~ ~

v v

~

~ ~

V

V

~ ~

V

V

V

V

83

62

500

340

250

165

125

83

62

35

40

84

70

65

50

45

35

40

Paral

**Ilel Lines** 

Parallel Lines with Dividers

Material Legend	<b>C</b> = Pure Copper <b>N</b> = Pure Nickel <b>G</b> = Pure Gold <b>P</b> = Cu with Palladium flash on one face
	<b>CG</b> = Copper with pure Gold flash on one side <b>NG</b> = Nickel with pure Gold flash on one side

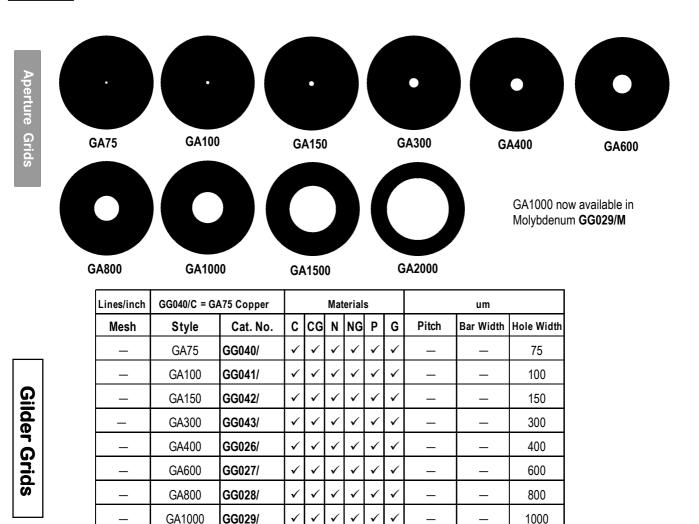
	G75/300 Lines/inch	GG0014/N = 0	G100/400 G75/300 Nickel			Ma	teria	als				um	]
	Mesh	Style	Cat.no.	С	CG	-	-	G	Ρ	G	Pitch	Bar width	
	75-300	G75/300	GG014/	<ul> <li>Image: A start of the start of</li></ul>	~	~		/	~	~	340-83	50-25	
	100-400	G100/400	GG015/	~	~	~		-	~	~	250-62	45-25	
100F						R C H J N F T Z							
	G100F1		G200F1		(	G200	)F2				G200HF	3	G200F4
	Lines/inch	GG0014/N = 0	G75/300 Nickel			Ма	teria	als			I	um	1
0	Mesh	Style	Cat.no.	С	CG	N	N	IG	Ρ	G	Pitch	Bar width	
	Alpha-nur	neric identifica	ation of each o	fsix	grid s	squa	ares						
	200	G200F1	GG032/	~	~	~	•	/	~	~	125	40-28	
	Alpha-nur	neric identifica	ation of each o	f nin	e gric	d squ	Jare	S					-
	200	G200F2	GG033/	~	~	~	•	/	~	~	125	25-12	
	200	G200HF3	GG064/	~	~	~	•			~	125		
	Alpha-nur	neric identifica	ation with lette	r ref.	alon	g ho	rizo	ntal	and	num	ber ref. al	ong vertica	al axis
	200/250	G200F4	GG073/	~	~	~	•	/	~	~	125-105	20-15	
GS1 x 0	0.2	GS1.5 x 0.3	GS2 x C	0.5		G	S2 x	0.75	5		GS2 x		GS2 x 1.5
	Lines/inch	GG014/N = G75/	1	_	r r	Mater			<u> </u>		<u></u> г	um	GS2x1 now available in
	Mesh	Style	Cat. No.	C	CG		NG		G	Р	itch B	ar Width	Molybdenum
3	_	GS1 x 0.2	GG065/	✓ ✓	✓ ✓	✓	<ul> <li>✓</li> </ul>	<ul> <li>✓</li> </ul>	<ul> <li>✓</li> </ul>		-	_	GG030/M
	—	GS1.5 x 0.3	GG066/	✓ 	<ul> <li>✓</li> </ul>	✓	✓	<b>√</b>	<ul> <li>✓</li> </ul>		-	_	
5	—	GS2 x 0.5	GG031/	✓ 	✓	✓	✓	<b>√</b>	<ul> <li>✓</li> </ul>		-	_	
	_	GS2 x 0.75	GG067/	✓ ✓	✓ ✓	✓ ✓	✓	✓	<ul> <li>✓</li> </ul>		-	_	
	_	GS2 x 1	GG030/	✓	✓	✓	✓	✓	✓		—	_	
	_	GS2 x 1.5	GG068/	$\checkmark$	$\checkmark$	$\checkmark$	$\checkmark$	$\checkmark$	$\checkmark$	1	-	_	

\_\_\_\_\_

1.13

**Gilder Grids** 

1



## **Carbon Nylon Grid**

~

 $\checkmark$ 



\_

Carbon coated nylon 200 mesh grid 3.05mm diameter, used for low background support membranes. These grids are of woven construction and may exhibit mechanical instability if subjected to an intense electron beam.

~

G077 Carbon nylon grid

GG044/

GG045/

GA1500

GA2000

tube of 25

\_

1500

2000

### **Carbon Composite Grid**

These are rigid carbonaceous grids of 75 mesh. They have no titanium contamination and are thermally stable.

G138 Carbon composite 75 mesh grid

each

Material LegendC = Pure CopperN = Pure NickelG = Pure GoldP = Copper with Palladium flash on one faceCG = Copper with pure Gold flash on one sideNG = Nickel with pure Gold flash on one side

## Synap Tek Grids

These ultra-rigid grids have a thickness of 0.114mm and are made from a beryllium-copper alloy with many features and formvar film stress is also materially reduced. The grids are very stable in the electron beam, contamination free and reusable after cleaning. All grids are 3.05mm diameter, with a 2 x 1mm slot ( $0.5 \times 2$ mm are also available)

#### **5 Types with Special Markings**

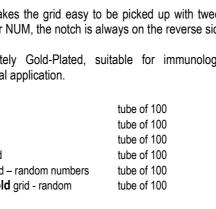
The DOT variety has two clear dots on one side, visible to the naked eye, so that the side of the grid being used is easily identified. Another variety NUM has random numbers on one side in place of the dots.

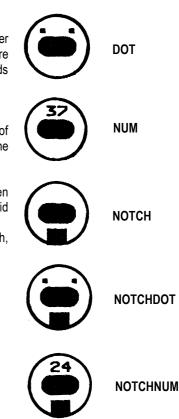
#### Undercut

An undercut notch on one side makes the grid easy to be picked up with tweezers. When the NOTCH is together with DOT or NUM, the notch is always on the reverse side of the grid to the markings.

The GILDED grids are completely Gold-Plated, suitable for immunology research, autoradiography or any other special application.

G089	Synap Tek DOT grid	tube of
G090	Synap Tek NUM grid	tube of
G091	Synap Tek NOTCH grid	tube of
G092	Synap Tek NOTCHDOT grid	tube of
G093	Synap Tek NOTCHNUM grid – random numbers	tube of
G094	Synap Tek NOTCHNUM gold grid - random	tube of





## Aluminium and Beryllium Grids

These materials with low atomic number elements are especially useful for X-ray analysis to reduce the background counts.

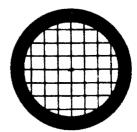
## **Aluminium Grids**

A selection of etched aluminium grids are shown on page 1.2

## **Beryllium Grids**

For the most critical work requiring the lowest background count, beryllium offers the best choice. All are 3.05mm diameter.

G080	Beryllium 75 mesh grid	each
G115	Beryllium 150 mesh grid	each
G116	Beryllium 2 x 1mm slot grid	each
G169	Beryllium 200 mesh grid	each



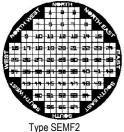
## Stainless Steel Grids

A selection of etched stainless steel grids are shown on page 1.2 and 1.8

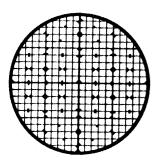
Also available are 200 mesh 3mm diameter grids stamped out from woven mesh, these provide an economical alternative to etched grids.

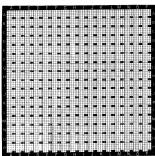
G170 Stainless steel 200 mesh grid

tube of 100



When ordering please specify material. C=Cu N=Ni G=Au. e.g. G271/C for copper, /N for nickel and /G for gold.





## Molybdenum Grids

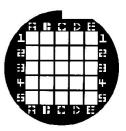
A selection of etched molybdenum grids are shown on page 1.2 and 1.8. Also available are 100 mesh 3mm diameter grids stamped out from woven mesh, these provide an economical alternative to etched grids.

G171 Molybdenum 100 mesh grid tube of 100

## Finder Grids in Cu, Ni, Au

Two grids designed to aid in identification and localisation of SEM specimens when placed on SEM stubs. The SEMF2 is for particles and suspensions whilst SEMF3 uses an alpha numeric index allowing up to 25 predetermined specimens to be fixed and located in the SEM.

G271/ Type SEMF2. Larger cells are identified using numbers from 1<57. Each large cell is subdivided into 4, making a total of 228 identifiable cells. Overall diameter 10mm, thickness ~50µm. 10 grids/vial, 5 for gold.



Type SEMF3

G272/ Type SEMF3. 25 cells are identified by their alpha numeric position. The asymmetric cut-out in the rim enables the right view to be obtained when placing on a SEM stub. Overall diameter 10mm, thickness ~50µm. 10 grids/vial, 5 for gold.

#### Finder Grids for SEM

See also page 10.10

A valuable tool for analytical studies. The grids are 10mm diameter and can be placed directly on the SEM stub surface and used to identify the area of interest.

G135/C SEM finder grids, Cu

G135/N SEM finder grids, Ni

tube of 25 tube of 25

each

each

### LM-SEM Locator Grid

A large locator grid approximately 65 x 65mm with small squares of 0.8mm. Delineation of 5 x 5 small squares gives unique area labelling which is very useful when comparing LM and SEM images.

G167/C LM-SEM grid, Cu G167/N LM-SEM grid, Ni

### Finder Grid for SEM Specimens

SEM specimens when relatively large can have a rather small area of interest for viewing. This type of grid has been designed to assist in finding the area of interest.

A central annulus surrounds the required area, with small pointer for orientation purposes. The long arms are tapered to show the direction in which to move, and are identified by N,S,E,W. Two small markers of lengths 500µm and 300µm are incorporated in the central ring. G168 SEM finder grid tube of 5

### Finder Grid for TEM Specimens G100F1

GG074/P G100F1 Cu/Pd (100)

Each of the 60 grid squares is identified using a base two binary numbering system. The six binary number symbols appear on the bottom grid bars along the horizontal axis. Zero (0) is represented by a short pillar and one (1) by a longer pillar. The inset view shows grid square nine (9) where the long pillar at the right represents decimal 1 and the long pillar fourth from the right decimal 8. Overall diameter 3.05mm Mesh 100 lines/inch Pitch 250 µm Bar width vert axis 40µm Hole width vert axis 210µm GG074/C TEM finder grid G100F1 Cu (100) GG074/G G100F1 Au (50) GG074/N G100F1 Ni (100)



## **TAAB Filmed/Coated Grids**

#### Formvar Support Films

Quantity	Copper Grid				
	100 mesh	200 mesh	300 mesh	400 mesh	
25	F231/025	F218/025	F232/025	F233/025	
50	F231/050	F218/050	F232/050	F233/050	
100	F231/100	F218/100	F232/100	F233/100	
	Nickel Grid				
25	F231/N025	F218/N025	F232/N025	F233/N025	
50	F231/N050	F218/N050	F232/N050	F233/N050	
100	F231/N100	F218/N100	F232/N100	F233/N100	
	Gold Grid				
25	F231/G025	F218/G025	F232/G025	F233/G025	
50	F231/G050	F218/G050	F232/G050	F233/G050	

Formvar/Carbon Support Films

Phone: +44 (0) 118 981 7775

TAAB can offer high quality support films of formvar, formvar/carbon or pure carbon on a wide range of grid styles and makes depending on customer choice.

TAAB **carbon** films are limited to a maximum mesh size of 200 as our experience indicates that larger mesh sizes overstress the carbon and result in splits, tears or other problems either in manufacture, transit or the EM.

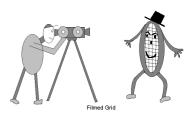
Plain **formvar** or **formvar/carbon** can be placed on most types of grid. Please ask for quotation if not listed.

ſ	Quantity		(	Copper Grid			
		100 mesh	100Hex	200 mesh	300 mesh	400 mesh	2 x 1mm
	25	F200/025	F180/025	F077/025	F196/025	F098/025	F144/025
	50	F200/050	F180/050	F077/050	F196/050	F098/050	F144/050
ĺ	100	F200/100	F180/100	F077/100	F196/100	F098/100	F144/100
				Nickel Grid			
	25	F200/N025	F180/N025	F077/N025	F196/N025	F098/N025	F144/N025
	50	F200/N050	F180/N050	F077/N050	F196/N050	F098/N050	F144/N050
	100	F200/N100	F180/N100	F077/N100	F196/N100	F098/N100	F144/N100
ſ	Gold Grid						
ĺ	25	F200/G025	F180/G025	F077/G025	F196/G025	F098/G025	F144/G025
ſ	50	F200/G050	F180/G050	F077/G050	F196/G050	F098/G050	F144/G050



Quantity			Copper Grid			
ľ	100 mesh	100 Hex	200 mesh	300 mesh	400 mesh	2 x 1mm
1	-	_	C101/001	C267/001	C169/001	_
25	-	_	C101/025	C267/025	C169/025	_
50	-	_	C101/050	C267/050	C169/050	_
100	-	-	C101/100	C267/100	C169/100	_
			Nickel Grid			
1	-	-	C101/N001	C267/N001	C169/N001	_
25	-	-	C101/N025	C267/N025	C169/N025	_
50	-	-	C101/N050	C267/N050	C169/N050	_
100	-	-	C101/N100	C267/N100	C169/N100	_
	Gold Grid					
1	-	-	C101/G001	C267/G001	C169/G001	_
25	-	-	C101/G025	C267/G025	C169/G025	_
50	-	_	C101/G050	C267/G050	C169/G050	-

#### **Carbon Support Films**



Standard carbon films are ~ 17-20nm thick but 30nm is available on request

#### For optically flat, mechanically and solvent resistant electron transparent specimen supports, see our Silicon Nitride Windows page 1.27

#### Also see Quantifoil or C-Flat Ultra Flat Carbon Grids

### Nitro-Cellulose/Carbon

Mounted on 200 mesh 3.05mm copper grids		
N056	Nitro-cellulose/Carbon film on 200 mesh cu grid	25
N056/1	Nitro-cellulose/Carbon film on 200 mesh cu grid	100

## Silicon Monoxide

Mounted on 400 mesh 3.05mm copper grids

For certain applications silicon monoxide offers an exceptionally clean film and being carbon free, is valuable in some microanalysis investigations

50

**S531** Silicon monoxide film on 400 mesh cu grid

Film Making Materials

#### POWDERS

F004	Formvar	100g
F005	Formvar	25g
	native support film material to Formvar is Butvar B98 as repo	
Ultrami B026	crotomy 4,479 (1979). Exhibits good mechanical and high ele Butvar B98	
DU20	Bulval B90	100g
C282	Collodion	25g
SOLU	TIONS	
F145/0	25 Formvar in chloroform 0.25%	100ml
F145/0	<b>50</b> Formvar in chloroform 0.50%	100ml
F145/1	00 Formvar in chloroform 1%	100ml
F145/H	AZ Formvar in chloroform****	4 x 25ml
F244/0	25 Formvar in ethylene dichloride 0.25%	100ml
F244/0	50 Formvar in ethylene dichloride 0.50%	100ml
F244/1	00 Formvar in ethylene dichloride 1%	100ml
F244/H	<b>AZ</b> Formvar in ethylene dichloride****	4 x 25ml
C171/0	<b>25</b> Collodion in amyl acetate 0.25%	100ml
C171/0	50 Collodion in amyl acetate 0.50%	100ml
C171/1	00 Collodion in amyl acetate 1%	100ml
C171/2	00 Collodion in amyl acetate 2%	100ml
C171/H	AZ Collodion in amyl acetate ****	4 x 25ml

Other strengths of solution can be made to order, please enquire.

\*\*\*\* Any of the above solutions can be packed in 25ml bottles 4 to a pack to avoid its classification as a hazardous chemical for shipping purposes. Please quote the relevant catalogue number and specify when ordering the strength of solution required.







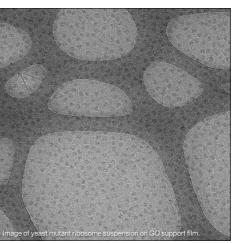
### Graphene and Graphene Oxide Coated Grids

There are currently two Graphene substrates available - Graphene Oxide (GO) and CVD (chemical vapour deposition). Graphene oxide films are typically laid down on lacey carbon films in suspension form with micrometer sized flakes with a less controlled thickness and evenness of coverage over the grid. CVD Graphene oxide on the other hand are produced by oxidizing CVD Graphene films at relatively low temperatures in oxygen (typically 200°C or less). These are continuous films and typically have well characterized hydrophilic properties which is important for wetting the surface of the Graphene oxide film. This property aids in the dispersion of nano particles for example but is also important for cellular biology and protein chemistry applications. GO films are generally less costly than CVD Graphene.

### **Graphene Oxide Support Films**

Graphene oxide (GO) provides a thinner support film but has a higher mechanical strength, electrical and thermal conductivity compared with support films made from other materials. TAAB Graphene Oxide support films are available on holey and lacey carbon and Quantifoil® support films. These new GO films are hydrophilic and ideally suited to imaging of small nanoparticles, nanowires and suspensions. Their low atomic number and thin-layer thickness result in significantly lower background contrast than conventional supports. GO support films are also ideal for Cryo TEM studies. The vitreous ice layer can be significantly thinner on GO support films providing higher contrast and hence higher resolution for structural determination.

Graphene offers some unique advantages for studying interactions and processes at the atomic level. As the first readily available two-dimensional material, it is a model system for transmission electron microscopy studies; it is almost electron transparent enabling other species to be resolved on its surface with atomic resolution. It is also a welldefined surface, allowing surface science techniques to be integrated with high resolution transmission electron microscopy and scanning probe microscopy.



G203/25 Graphene oxide film on lacev carbon on 400 mesh Copper pack of 25 G204/10 Graphene oxide film on Quantifoil R 2/2 on 300 mesh Cu pack of 10

## Graphene TEM Support Films

Our Graphene TEM support films are supported by a lacey carbon film on a 300 mesh copper grid. The single, continuous Graphene sheet covers the entire 300 mesh area of the TEM grid. This creates a usable area of around 75% of the TEM grid, leaving plenty of space for specimens or experiments. These Graphene TEM support films with the large area continuous film can be used directly out of the box. The continuous Graphene film represents a more practical Graphene support film compared to the Graphene enhanced lacey carbon supports.

The Graphene films are available with either 1, 2, 3-5 or 6-8 layers of Graphene. The 2 layer Graphene is ideally suited for high resolution TEM imaging, imaging of nanoparticles and imaging of weak contrast materials. Graphene exhibits excellent conductivity and very high transparency for electrons. The more robust 3-5 and 6-8 layer Graphene are offered for use as an experimental platform for Graphene research. It can be used for nano scale experiments or Graphene applications research with subsequent high resolution imaging.

The Graphene used for these Graphene TEM support films is grown on copper foil using a CVD process. The Graphene is then released by dissolving the copper foil and transferred onto the lacey carbon/300mesh grid by using a proprietary transfer technique.

#### **Graphene Specifications**

scotch tape method)

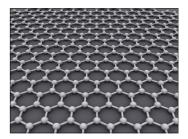
The sheet resistance for a single layer of the Graphene Film is  $600\Omega/sq$ Thickness for the single layer of Graphene is normally approx. 0.35nm Transparency of the single layer of Graphene is approx. 96.4% Thickness for the 2 layers of Graphene is normally approx. 0.7nm

- Transparency of the 2 layers of Graphene is approx. 92.7%
- Thickness for the 3-5 layers of Graphene is between 1.0 1.7nm

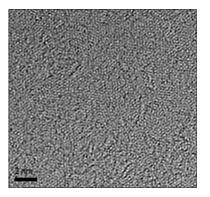
Transparency of 3-5 layers of Graphene is in the range of 90.4 - 85.8%

Thickness for the 6-8 layers of Graphene is between 2.1 - 2.8nm

Transparency of 6-8 layers of Graphene is in the range of 83.2 - 78.5% The Graphene has an in-plane modulus of 0.9TPa (compared with 1.0 TPa for Graphene produced by the

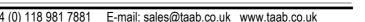


Crystalline structure of Graphene Film



High resolution TEM image of 3-5 layer Graphene. Marker bar = 2nm.

Continued over page

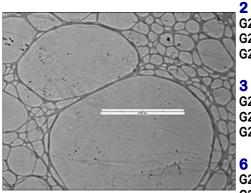




## **Grids & Specimen Supports**

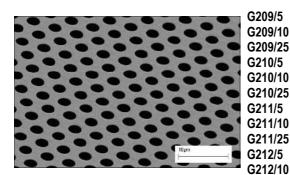
#### Graphene Films on Grids

All films are or	n lacey carbon 300 mesh copper grids. Available in packs of 5, 10 or 25
in grid box.	
G205/5	Single layer Graphene on 300 mesh lacey carbon pack of 5
G20510	Single layer Graphene on 300 mesh lacey carbon pack of 10
G205/25	Single layer Graphene on 300 mesh lacey carbon pack of 25



3-5 layer Graphene on Lacey Carbon film. Marker bar =  $5\mu$ m

#### Graphene Films on Holey Silicon Nitride



G212/25

Holey Silicon Nitride Support

# Graphene Films on Ultra-flat SiO<sub>2</sub> Substrate



#### 2 Layer Graphene Support Films

Single Layer Graphene Support Films

206/5	Two layer Graphene on 300 mesh lacey carbon pack of 5
206/10	Two layer Graphene on 300 mesh lacey carbon pack of 10
206/25	Two layer Graphene on 300 mesh lacey carbon pack of 25

#### 3 to 5 Layer Graphene Support Films

G207/5	3-5 layer Graphene on 300 mesh lacey carbon pack of 5
G207/10	3-5 layer Graphene on 300 mesh lacey carbon pack of 10
G207/25	3-5 layer Graphene on 300 mesh lacey carbon pack of 25

#### 6 to 8 Layer Graphene Support Films

G208/5	6-8 layer Graphene on 300 mesh lacey carbon pack of 5
G208/10	6-8 layer Graphene on 300 mesh lacey carbon pack of 10
G208/25	6-8 layer Graphene on 300 mesh lacey carbon pack of 25

**Graphene supported by Holey Silicon Nitride** which has 2.5µm holes with a 4.5µm pitch in 200nm Si3N4 over a 0.5 x 0.5mm window size. The Graphene sheet covers the complete window with the ultraflat Si3N4 holey membrane and leaves free standing Graphene covering the 2.5µm holes. Total usable area is approx. 75% due to unavoidable folds and wrinkles in the Graphene sheet. Available with single, 2, 3-5, and 6-8 layer Graphene sheets. Research-ready product, suitable for UHR imaging or as ultra-flat experimental platform. Graphene specification as for above 300 mesh lacey carbon.

Single Layer Graphene on Holey Silicon Nitride as above pack of 5
Single Layer Graphene on Holey Silicon Nitride as above pack of 10
Single Layer Graphene on Holey Silicon Nitride as above pack of 25
2 layer Graphene on Holey Silicon Nitride as above pack of 5
2 layer Graphene on Holey Silicon Nitride as above pack of 10
2 layer Graphene on Holey Silicon Nitride as above pack of 25
3-5 layer Graphene on Holey Silicon Nitride as above pack of 5
3-5 layer Graphene on Holey Silicon Nitride as above pack of 10
3-5 layer Graphene on Holey Silicon Nitride as above pack of 25
6-8 layer Graphene on Holey Silicon Nitride as above pack of 5
6-8 layer Graphene on Holey Silicon Nitride as above pack of 10
6-8 layer Graphene on Holey Silicon Nitride as above pack of 25

Graphene on Ultra-flat SiO<sub>2</sub> substrate offered for use as a research-ready experimental platform. The Graphene sheet covers the complete 5 x 5mm diced substrate. Total usable area is approx. 75% due to unavoidable folds and wrinkles in the Graphene sheet. Suitable for AFM imaging or as ultra-flat experimental platform. The Specification of the Graphene is the same as mentioned above. Supplied in a Gel-Pak box and packed in class 10 clean room conditions. Consists of a 200nm thermally grown SiO<sub>2</sub> film on an ultra-flat silicon wafer with a normal thickness of 675  $\mu$ m.

G213/5Single Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 5G213/10Single Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 10G213/25Single Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 25G214/52 Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 5G214/102 Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 5G214/102 Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 10G214/252 Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 10G214/253-5 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 5G215/103-5 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 10G215/253-5 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 25G216/56-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 25G216/56-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 5G216/106-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 5G216/266-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 25G216/266-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 10G216/266-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 25



20 sheets

20 sheets

20 sheets

pack of 10

10 sheets

50

50

50

50

50

50

1

### **Mica Sheets**

High grade mica for making freshly cleaved surfaces for such EM applications as carbon filming and particle spraying. Also suitable for high reolution AFM studies, growing cells and thin film coating research.

Available in the following sizes as stock items, other sizes can be supplied please enquire.

- M054 Mica 3" x 1" x 0.006" thick (75 x 25 x 0.15mm) M055 Mica 1" x 1" x 0.006" thick (25 x 25 x 0.15mm)
- M459 Mica 11 x 11 x 0.15mm thick
- M460 Mica 100 x 20 x 0.15mm thick
- M461 Mica 150 x 150 0.15mm thick
- M462 Mica 9.9mm dia x 0.1mm thick
- M463 Mica 20 x 20mm thick ultra clean

### Lacey Carbon Films

These are carbon films with large holes, which make them particularly suitable for the support of acicular crystals. Much of the crystal is unsupported and therefore subject to a minimum of incoherent scattering from the film.

C269/C Lacey carbon film 300 mesh, 3.05mm, Cu	50
C269/N Lacey carbon film 300 mesh, 3.05mm, Ni	50
C270/C Lacey carbon film 400 mesh, 3.05mm, Cu	50
C270/N Lacey carbon film 400 mesh, 3.05mm, Ni	50
C270/G Lacey carbon film 400 mesh, 3.05mm.Au	50

## **Holey Carbon Films**

These are similar to lacey carbon films with smaller holes. C062/C Holey carbon film 300 mesh, 3.05mm, Cu C062/N Holey carbon film 300 mesh, 3.05mm, Ni C062/G Holey carbon film 300 mesh, 3.05mm.Au C274/C Holey carbon film 400 mesh, 3.05mm, Cu C274/N Holey carbon film 400 mesh, 3.05mm, Ni C274/G Holey carbon film 400 mesh, 3.05mm.Au

## Grid Coating Pen

The Grid Coating pen improves the adherence of tissue sections onto the grids. With a touch of the pen to the grid, a thin layer of coating is applied to the grid. Drying takes place in 1-2 minutes at room temperature. After it has dried the grid is ready for section mounting. The pen can also be used in pretreating grids prior to mounting support films such as formvar and carbon. This minimises dislodging, widening or breaking of the support film.

P293 Grid Coating Pen

## **Grid Coating Stand**

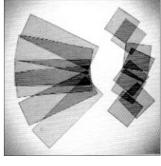
A stand designed with 49 recessed holes suitable for 3.05mm diameter grids. A groove is carefully machined to the correct depth which allows safe and easy access for tweezer manipulation of the grids.

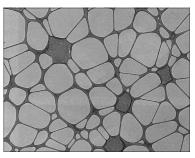
Standing on 3 integral feet it is easily placed in a low glass dish to allow thin collodion or formvar films to be lowered onto the grids by siphoning off the water. The coated grids can then be transferred to the coating unit.

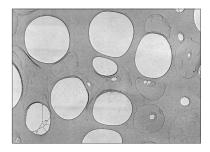
Fax: +44 (0) 118 981 7881 E-mail: sales@taab.co.uk

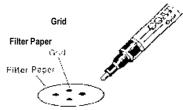
G122 Grid coating stand, thin film

Phone: +44 (0) 118 981 7775





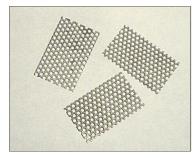






www.taab.co.uk

20 sheets 3 sheets



## **Grid Coating Plate**

Made from nickel, these perforated plates are very useful in the preparation of grid coating. The plate is placed under distilled water and the surface supporting the film is gradually lowered. Excess water is removed by blotting from below. The plate containing filmed grids can be transferred to a vacuum coating unit for carbon coating or to a freeze-drying unit.

G107 Grid coating plate pack 3



Designed to store or transport grids this TAAB box has an indexed silicone rubber plate housed in a transparent viewing box with hinged lid. The silicone rubber plate is divided into 54 individual compartments of 10mm square, each

compartment capable of holding 3 grids. Grids adhere well to the silicone rubber plate and grids cannot migrate from one square to another when the lid is closed and it is easy to pick up grids without damaging tweezer tips.

Overall size of box: 95 x 70 x 6mm deep. Comes complete with a record card.

G117	Grid transporting box	each
G117/1	Grid transporting box	per 10



## **Grid Plate**

Round silicone rubber indexed grid storage plate numbered. Available in two sizes 85mm and 45mm diameter which are supplied mounted in either 90mm or 50mm plastic Petri dish or supplied loose. This is an ideal way of storing "working grids" or staining grids. The grids adhere lightly to the silicone plate, which eliminates the problem of grids jumping. The grids are easily picked up without damaging the tweezer tips or the grid.

G082 plate has 16 x 14mm squares and the G125 plate has 9 x 10mm squares. The plates can easily be washed clean.

Please note: Not recommended for storing grids which are to be used in X-ray microanalysis work due to Silicone rubber contamination.

Grid plate,(85mm) in Petri dish	each
Grid plate,(85mm) in Petri dish	pack 10
Grid plate,(85mm) - loose	pack 10
Grid plate, (45mm) in Petri dish,	each
Grid plate, 45mm) - <b>loose</b>	pack 10
	Grid plate,(85mm) in Petri dish Grid plate,(85mm) - <b>loose</b> Grid plate,(45mm) in Petri dish,

### Grid Storage **Boxes**

See also page 1.26





## **BEEM Dial-a-Grid Box**

Indexed grid box containing 24 letter-labelled crossed slots, which accommodate 3.05mm in one direction and 2.3mm in the other. The grids are accessed one at a time through a hole in the clear rotating protection disc . The box is totally enclosed by a hinged lid making the box fully dust proof.

Dimensions; 57 x 45 x 12.5mm high.

G114 BEEM Grid storage box each

## **Specimen Grid Box**

These boxes hold up to 100 grids in numbered holes, designed to take either 3.05mm or 2.3mm grids accessed a row at a time through a slot in the sliding cover. Dimensions; 85 x 58 x 7mm high. Complete with grid recording card.

G062	Specimen grid box	each
G063	Specimen grid box	per 10



## Numbered Specimen Grid Box

Identical to G062 but with a unique number printed on the face and one end. Advantages:

- Eliminates the placement of the specimen grid in the wrong box
- Easy retrieval of grid box from storage
- Complete with grid storage card

Dimensions; 85 x 58 x 7mm high.

G120 Specimen grid box, numbered. G121 Specimen grid box, numbered.

each per 10

## **LKB/LEICA Specimen Grid Box**

Storage for 100 grids in 5 straight columns of 20 slots all referenced. Takes both 3.05mm and 2.3mm diameter grids.

Dimensions; 80 x 50 x 7mm high.

G133 LKB/Leica grid storage box

G133/1 LKB/Leica grid storage box.

per 10 each

each

## **Specimen Grid Box**

Storage for 50 grids. Takes both 3.05mm and 2.3mm diameter grids. The box is manufactured from a plastic having a low susceptibility to charging. All holes are numbered.

G126 Specimen grid storage box - 50 grids

**Grid Staining System** 

Designed to handle up to 25 grids at one time or as few as a single one. The Matrix has the following features:

- \* Greatly reduces the chance of mechanical damage
- \* Ensures equal staining and rinse times

\* Has a simple alpha-numeric system for easy identification of each grid.

The plastics used are not acid-resistant and are designed for aqueous solutions only. Note: Do Not use alcohol- based stains; they will damage or destroy the staining vessels. One vessel could, for example, be used for uranyl acetate and the other one for lead citrate.

G270 Grid staining system GG270/C Replacement staining vessels - 1 red and 1 blue

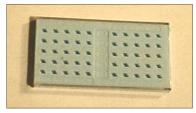
### **Zerostat Anti-Static Gun**

Anti-static generator for neutralising static charges of either polarity on any insulating surface. Use to reduce the risk of grids jumping out of boxes and to eliminate a block charging defect during ultramicrotomy.

G083 Zerostat gun

each







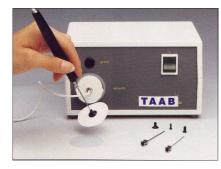








## **Grids & Specimen Supports**





Useful for handling without damage, small, delicate items i.e. grids, specimens etc. The suction can be applied through a selection of either fine tubes or rubber suckers actuated by covering the hole in the tube with a finger. The object being lifted is released by lifting the finger from the hole. Nozzle sizes are 0.4mm, 0.7mm and 1.0mm.

T106	Vacuum tweezer – 240 volt model
T106/1	Vacuum tweezer – 110 volt model
T106/S	Set of spare nozzles and tubing

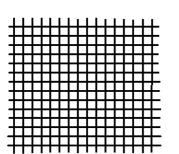
Settlement Dish

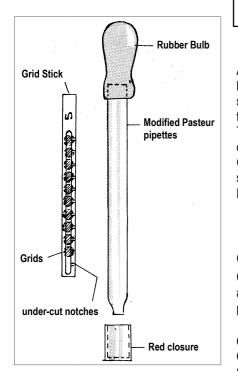
Settlement dish, 135mm diameter with drain tap. Useful for removing distilled water when preparing formvar, butvar or collodion support films, or for floating down stripped carbon films on to TEM grids.

D195 Dish, settlement, 135mm diam. glass.

each

each each set





## **Stainless Steel Mesh**

A fine but rigid stainless steel mesh 150 x 150mm square with a mesh size of approximately 0.5mm that can be used with the settlement dish as a support to receive the grids after they are placed on the support film.

Can also have other uses within the laboratory

W100 150 x 150mm stainless steel mesh 3 pieces

## Gridstick

An economical and simple solution to staining multiples of grids.

A SynapTek Grid Staining Stick is a device which can take up to 10 grids held to the stick by a self adhesive glue which withstands all organic solvents remains effective for at least six uses. The grids are loaded onto one side of the Grid Stick with the aid of tweezers and they can be processed *in situ* throughout the staining, washing and drying procedures. The loaded Grid stick is placed inside a modified pipette which has a rubber bulb fitted to one end. It is now a simple operation to pipette the relevant fluids around the grids. The Grid sticks are provided with undercut notches to facilitate easy removal of grids from the stick with tweezers.

Each kit comprises;-

5 Pre-coated Grid Sticks, inside five pipettes with red closures.

10 Modified Pasteur pipettes - five for Uranyl Acetate and five for Lead Citrate 2 Rubber bulbs with flow limiting plugs

Other possible uses;-

Collecting serial sections - Grid support for carbon coating - Emulsion coating for autoradiography - Preliminary inspection of biological material at the light level - using a phase microscope - Special staining procedures.

G088Gridstick kitG088/GGridstick adhesive 5mlG088/SGridsticks uncoated pack of 10

Light Micrograph Of Grid Mesh

### New High Mesh Grids with much improved transmission values

There is an increasing interest in life sciences, material science, semi conductor and nanotechnology for specialised supports with high mesh values and with greater transmission performance. To meet this demand TAAB introduces three new products from Gilder Grids designed to improve support for thin specimens and membranes by having high hole/bar ratios that give good transmission values. They are **available in copper, nickel and gold.** 

Type G1500HH Hexagonal Mesh 15 grids/vial

3.05mm

2mm

~1,500

16.5µm

~10.5µm

~6µm

Type G2000HA Circular holes 10 grids/vial

3.05mm

2mm

~2,000

12.5µm

~6.5µm

~6µm

Overall diameter3.05mmMesh diameter2mmLines/inch~1,000Pitch25µmBar width~6µmHole width~19µm

Overall diameter

Mesh diameter

Lines/inch

Bar width

Hole width

Overall diameter

Mesh diameter

Lines/inch

Bar width

Hole width

Pitch

Pitch

GG075/C Gilder grid G1000HH Cu

GG075/N Gilder grid G1000HH Nickel

GG075/G Gilder grid G1000HH Gold

GG077/C Gilder grid G1500HH Cu

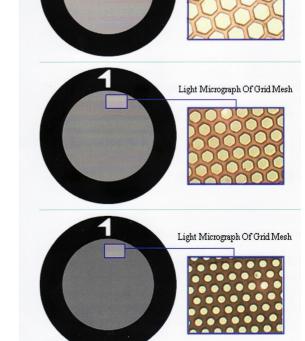
GG077/N Gilder grid G1500HH Nickel

GG077/G Gilder grid G1500HH Gold

GG076/C Gilder grid G2000HA Cu

GG076/N Gilder grid G2000HA Nickel

GG076/G Gilder grid G2000HA Gold



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## **Grids & Specimen Supports**

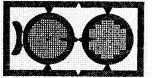
#### **Extended Maxtaform Range of Research Grids**

Maxtaform have increased their range of patterns and mesh sizes in a wide variety of metal foils. There are also mesh sizes from 50 to 600, solid grids with holes 0.4 to 2mm, finder grids with various patterns and folding grids with or without handles. materials include copper, nickel, gold, titanium, molybdenum, stainless steel, aluminium and copper/rhodium.









#### <u>New</u> 600 Mesh Grids

Without handles in copper (1GC600), nickel (1GN600) and copper/rhodium (1GC/Rh600) With handles in copper (3HGC600), nickel (3HGN600 and copper/rhodium (HGC/Rh600)

#### <u>New 300 & 400 Mesh Grids</u>

300 mesh - 1GT300 titanium, 1GA300 aluminium and 1GS300 stainless steel 400 mesh - 1GT400 titanium and 1GS400 stainless steel

#### New 75/300 Staggered Mesh Grids

Available in Copper, Copper/Rhodium, Nickel and gold (see table below)

#### New H12 Folding Grids

A combination of H1 and H2 grids in folded format. LH grid is standard 200 mesh, RH grid is 200 mesh reference pattern. Available in Copper, Copper/Rhodium or Nickel.

#### New IG15H with Handle

1.5mm hole grid in Copper and Nickel with handle. Also available in Cu/Rh, Au, Al, SS, Mo and Ti - please ask.

#### <u>New</u> HF49 Slot Grid now in Copper/Rhodium

2 x 1mm slot

Pattern	Cat. no.	Pitch (µm)	Mesh (µm)	Hole (µm)	Bar (µ)	Transmissio n %	Tol'an ce	Qty/ vial
1GC600	GE047/C	41	600	26	15	42	±5µm	100
1GN600	GE047/N	41	600	26	15	42	±5µm	100
3HGC600	GE048/C	41	600	26	15	42	±5µm	100
3HGN600	GE048/N	41	600	26	15	42	±5µm	100
1GA300	G009/A	85	300	54	23	40	±5%	25
1GT300	GE009/T	85	300	54	31	40	±5µm	25
1GS300	GE009/S	85	300	54	31	40	±5µm	25
1GA400	GE011/A	64	400	38	30	35	±5µm	25
1GT400	GE011/T	64	400	38	21	35	±5µm	25
1GS400	GE011/S	64	400	38	21	35	±5µm	25
H12 Cu	GM046/C	127/127	200	112/108	15/19	78/72	±2µm	25
H12 Cu/Rh	GM046/CR	127/127	200	112/108	15/19	78/72	±2µm	25
H12 Ni	GM046/N	127/127	200	112/108	15/19	78/72	±2µm	25
75/300 staggered Cu	GM047/C	339 x 85	75/300	284/55	30	55	±5µm	100
75/300 staggered Cu/Rh	GM047/CR	339 x 85	75/300	284/55	30	55	±5µm	100
75/300 staggered Ni	GM047/N	339 x 85	75/300	284/55	30	55	±5µm	100
75/300 staggered Au	GM047/G	339 x 85	75/300	284/55	30	55	±5µm	25
1GC15H	GM048/C			1500			±20µm	100
1GN15H	GM048/N			1500			±20µm	100
HF49Cu/Rh	GM049/CR			2000 x 1000			±10µm	100

1.26

125µm 35µm 90µm

#### **TEM Specimen Supports in Molybdenum**

We can offer a new range of four molybdenum grids from Gilder. These new products are manufactured using a process known as 'chemical milling' (etching) instead of the more familiar technique of 'electroforming' (deposition) used to make copper, nickel and gold products. Molybdenum is used principally in applications where resistance to high temperature and corrosion coupled with hardness and a low expansion coefficient are deemed to be important.. The material has a typical purity of 99.9%.

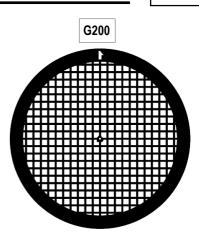
GG005/M	G200	Specifications	
Overall diameter	3.05mm	Pitch	125µm
Rim width	0.225mm	Bar width	35µm
Rim mark	yes	Hole width	90µm
Centre mark	yes	Overall thickness	25µm
Lines/inch	200		

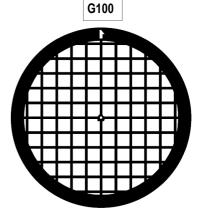
#### GG003/M

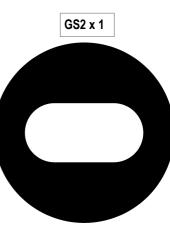
Overall diameter 3.05mm Rim width 0.225mm Rim mark yes Centre mark yes Lines/inch 100

G100

Pitch	250µm
Bar width	45µm
Hole width	205µm
Overall thickness	25µm







GG030/M GS2X1 Overall diameter 3.05mm Rim width N/A Rim mark N/A Centre mark N/A Lines/inch N/A

#### Specifications

Pitch	N/A
Bar width	N/A
Hole width	2 x 1mm
Overall thickness	50µm

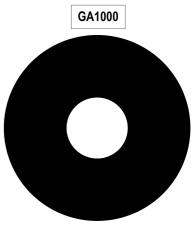
Overall diameter 3.05mm Rim width N/A Rim mark N/A Centre mark N/A Lines/inch N/A

Specifications

Pitch	N/A
Bar width	N/A
Hole width	1000µm
Overall thickness	50µm

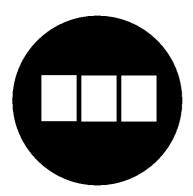
Symbol Mo Atomic no. 42 Melting Point 2617.0°C (2890.15.6°K, 4742.6°F) Boiling Point 4612.0°C (4885.15°K, 8333.6°F) Density 10.22g/cm<sup>2</sup>

G200



1.27

### New Slot Grid from Gilder



The new GS2/3X1 has two central bars to provide increased support enabling thinner support films to be used. Rigidity has been maintained by making the thickness ~  $50\mu$ m. Available in copper with a flash of palladium on one side, nickel and gold. The copper and nickel grids are also available with an immersion coating of gold to increase chemical resistance at an attractive price. Gold in vials of 50 grids, molybdenum in vials of 25, all other vials of 100.

Overall diameter 3.05mm, Hole sizes 606 x 1000µm

GG078/CGS2/3X1 Cu (100)GG078/NGS2/3X1 Ni (100)GG078/GGS2/3X1 Au (50)

**GG078/P** GS2/3X1 Cu/Pd (100) **GG078/M** GS2/3X1 Mo (25)





Each **SB50BN** storage box has a unique • number so no two boxes can ever be confused. **Specifications SB50 and SB50BN:** 

Size75mmL x 65mmW x 6.5mmDWeight22 gmMaterialsBase ABS-PHAT (Acrylonitrile Butadiene

Styrene + Anti-Static Additive *Clear cover* CAB (Cellulose Acetal Butyrate)



### **Specimen Grid Storage Boxes**

These new grid storage boxes are designed for the routine handling and long term storage of 50 standard size TEM grids. The ergonomic design incorporates several features that overcome the disadvantages associated with storage boxes of the more conventional 'sliding cover' design. Each **SB50BN** box has a unique number on the face and one end so no two boxes can ever be confused.

- Features:
- A blue arrow at the 12 0'clock position indicates the park position for the cover when not in use. This is a firm 'click' position and cannot be moved accidentally, thus preventing spillage.
- The clear cover can be rotated smoothly through 360° once the slight initial resistance of the park position has been overcome exposing a maximum of 2 or 3 diamond shaped holes at any one time.
- The materials have been chosen for their anti-static properties, the clear cover also having self lubricating properties which reduces friction enabling the cover to move freely whilst remaining in close contact with the face of the base.
- The diamond shaped holes have an alpha numeric referencing system and each box is supplied with an indexed record card for additional information.
  - The boxes are designed to be stacked with the base locating precisely over the face of another box.

G202 SB50 grid storage box (holds 50 grids) G202/BN SB50BN grid storage box with unique number (holds 50 grids)

## Lift-out Grid Storage Box

Storage box for 100 standard 3mm lift-out TEM grids. Complete with base, lid and clips. The grids are stored horizontally.

G117 Lift-out grid storage box



#### MEM Grid Box Multipurpose EM Specimen Grid Box

A newly designed Grid Box offering **safety**, **ease and convenience** – This EM specimen grid box is one of the most desirable boxes on the market. **Advantages:** 

- Eliminates the chances of tweezer insertion damaging the grids The 'tweezers slot' and 'grid slot' are in a separate location. The tweezers are only able to grip the edge of the grid enabling it to be picked up.
- Stored grids no longer jump out of the box when the cover is removed. There is a separate plastic cover between the box and the sliding lid which allows only four slots to be exposed at any time.
- The Grid Record Card is stored safely along on the reverse side of the box. Dimensions: 81mm L x 54mm W x 6mm Thick.

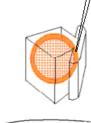
G279	MEM-96 can store up to store up to 96 grids	each
G279/10	MEM-96 to store up to 96 grids	10 pack
G280	MEM 32 can store up to 32 grids and 8 blocks	each
G280/10	MEM 32 to store up to 32 grids and 8 blocks	10 pack

When moving the plastic cover only four holes are exposed at any time

Record card is stored under the box



Slot grids are best gripped by curved tweezers, mesh grids by straight *or* curved tweezers.





### FIB Grid Storage Box

Storage box for four (4) FIB lift-out grids or half grids. Cavity depth is just 1.7mm, thus preventing grids from rotating. The diamond shaped cavities allow grids to be easily loaded or unloaded using fine tweezers.

**G277** FIB grid storage box

## Cryo Grid Boxes

These cryo grid boxes are used for transferring, storing and manipulating vitrified cryo TEM specimens made with cryo devices such as the FEI Vitrobot<sup>™</sup>, Gatan 626 or Gatan CT4500 cryotransfer systems and others.. There are two versions each with four storage positions. The circular box is the most widely used and is available with or without a non-static rotatable lid. All of the boxes have a 5/40 tap in the centre. On versions with lids, the lid is held in place with a stainless steel screw. They can also be used for storing or transporting small numbers of grids or specimens. A handling tool is available for the cryo grid boxes.

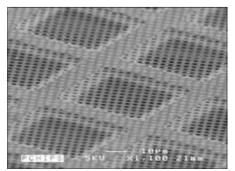
- G274 Cryo grid box with lid, circular
- G274/B Cryo grid box base only
- G278 Cryo grid box with pin type lid, circular
- G275 Cryo grid box with lid, square
- G276 Cryo grid box handling tool

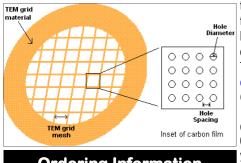




G276 Cryo grid box handling tool







#### **Ordering Information**

#### CF-MH-2C and CF-MH-4C

Multi-hole and space. The Multi-hole device has a staggered pattern of six features consisting of three circle patterns of 1µm, 1.4µm and 2µm diameter and three ellipse patterns of 1µm x 4µm, 1.4µm x 5.6µm and 2µm x 8µm.

G281/C25 CF-MH-2C Multi-hole on 200 mesh Cu grid (25) G281/C50 CF-MH-2C Multi-hole on 200 mesh Cu grid (50) G281C100 CF-MH-2C Multi-hole on 200 mesh Cu grid (100)

#### CF-1/1-2C and CF-1/1-4C (200 mesh Cu) (400 mesh Cu)

1.0µm hole, 1.0µm space

G283/C25 CF-1/1-2C 1µm hole x 1µm space on 200 mesh Cu grid (25) G283/C50 CF-1/1-2C 1µm hole x 1µm space on 200 mesh Cu grid (50) G283/C100 CF-1/1-2C 1µm hole x 1µm space on 200 mesh Cu grid (100)

CF-1.2/1.3-2C and CF-1.2/1.3-4C (200 mesh Cu) (400 mesh Cu)

#### 1.2µm hole, 1.3 µm space

G285/C25 CF-1.2/1.3-C 1.2µm hole x 1.3µm space on 200 mesh Cu grid (25) G286/C25 CF-1.2/1.3-4C 1.2µm hole x 1.3µm space on 400 mesh Cu grid (25) G285/C50 CF-1.2/1.3-C 1.2µm hole x 1.3µm space on 200 mesh Cu grid (50) G286/C50 CF-1.2/1.3-4C 1.2µm hole x 1.3µm space on 400 mesh Cu grid (50) G285/C100 CF-1.2/1.3-C 1.2µm hole x 1.3µm space on 200 mesh Cu grid (100) G286/C100 CF-1.2/1.3-4C 1.2µm hole x 1.3µm space on 400 mesh Cu grid (100)



#### 2.0µm hole, 0.5µm space

G287/C25 CF-2/0.5-2C 2µm hole x 0.5µm space on 200 mesh Cu grid (25) G287/C50 CF-2/0.5-2C 2µm hole x 0.5µm space on 200 mesh Cu grid (50) G287/C100 CF-2/0.5-2C 2µm hole x 0.5µm space on 200 mesh Cu grid (100)

G288/C25 CF-2/0.5-4C 2µm hole x 0.5µm space on 400 mesh Cu grid (25) G288/C50 CF-2/0.5-4C 2µm hole x 0.5µm space on 400 mesh Cu grid (50) G288C/100 CF-2/0.5-4C 2µm hole x 0.5µm space on 400 mesh Cu grid (100)

Images show C-flat™ mounted on a stub using carbon tape and imaged with a Field Emission Scanning Electron Microscope

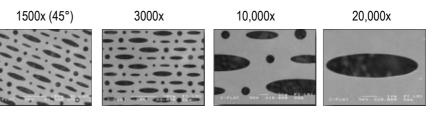


### Ultra Flat Holey Carbon Grids for Cryo TEM

C-flat<sup>™</sup> is an ultra-flat, holey, carbon-coated TEM support grid for transmission electron microscopy (TEM). Unlike some other holey carbon films, C-flat™ is manufactured without plastics, so it is clean and without residue. Made with patent pending technology, Cflat™ provides an ultra-flat surface that results in better particle dispersion and more uniform ice thickness. Patterning is done using deep-UV projection lithography, ensuring the most accurate and consistent hole shapes and sizes down to submicron features. The precise methods by which C-flat<sup>™</sup> is manufactured eliminate artefacts such as excess carbon and edges around holes.

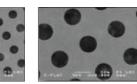
C-flat<sup>™</sup> holey carbon grids provide the ideal specimen support to achieve high resolution data in cryo-TEM making them an ideal choice for single particle analysis, cryo electron tomography and automated TEM analysis. C-flat™ is a holey carbon film supported by a standard TEM grid. C-flat™ products are fully specified by 4 parameters: the hole diameter and pitch of the holey carbon film plus the material type and mesh size of the TEM grid. Standard support thickness is 20nm but 40nm is available on request at extra cost (about 30%). Add postfix /T to existing code number e.g. G285/C50 becomes G285/C50/T. 40nm substrate available only in 50 and 100 quantities.

C-flat™ is available in several standard array patterns including hole diameters/hole spacings of 0.6/2, 1/1, 1/2, 1/4, 1.2/1.3, 2/1, 2/2, 2/4, 4/2, and a multi-hole pattern. C-Flat™ is supported by your choice of a 200 mesh or 400 mesh copper TEM grid and sold in quantities of 25, 50, or 100. Available on other grid materials (e.g. gold) to special order.

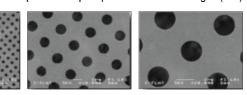


G282/C25 CF-MH-4C Multi-hole on 400 mesh Cu grid (25) G282/C50 CF-MH-4C Multi-hole on 400 mesh Cu grid (50) G282/C100 CF-MH-4C Multi-hole on 400 mesh Cu grid (100)





G284/C25 CF-1/1-4C 1µm hole x 1µm space on 400 mesh Cu grid (25) G284/C50 CF-1/1-4C 1µm hole x 1µm space on 400 mesh Cu grid (50) G284/C100 CF-1/1-4C 1µm hole x 1µm space on 400 mesh Cu grid (100)



#### C-flat<sup>™</sup> Ultra Flat Holey Carbon Grids Cont...

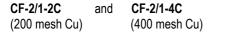
C-flat<sup>™</sup> is a trademark of Protochips, Inc. All rights reserved

3000x

1500x (45°)

10,000x

20,000x



#### 2.0µm hole, 1.0µm space

G289/C25 CF-2/1-2C 2µm hole x 1µm space on 200 mesh Cu grid (25) G289/C50 CF-2/1-2C 2µm hole x 1µm space on 200 mesh Cu grid (50) G289/C100 CF-2/1-2C 2µm hole x 1µm space on 200 mesh Cu grid (100)

CF-2/2-2C and CF-2/2-4C (200 mesh Cu) (400 mesh Cu)

2.0µm hole, 2.0µm space

G291/C25 CF-2/2-2C 2µm hole x 2µm space on 200 mesh Cu grid (25) G291/C50 CF-2/2-2C 2µm hole x 2µm space on 200 mesh Cu grid (50) G291/C100 CF-2/2-2C 2µm hole x 2µm space on 200 mesh Cu grid (100)

CF-2/4-2C CF-2/4-4C and (200 mesh Cu) (400 mesh Cu)

#### 2.0µm hole, 4.0µm space

G293/C25 CF-2/4-2C 2µm hole x 4µm space on 200 mesh Cu grid (25) G293/C50 CF-2/4-2C 2µm hole x 4µm space on 200 mesh Cu grid (50) G293/C/100 CF-2/4-2C 2µm hole x 4µm space on 200 mesh Cu grid (100)

CF-4/1-2C	and	CF-4/1-4C	No images
(200 mesh C	Cu)	(400 mesh Cu)	

#### 4.0µm hole, 1.0µm space

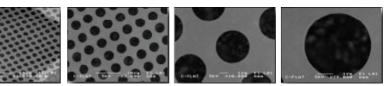
G295/C25 CF-4/1-2C 4µm hole x 1µm space on 200 mesh Cu grid (25) G295/C50 CF-4/1-2C 4µm hole x 1µm space on 200 mesh Cu grid (50) G295/C100 CF-4/1-2C 4µm hole x 1µm space on 200 mesh Cu grid (100)

and CF-4/2-4C CF-4/2-2C (400 mesh Cu) (200 mesh Cu)

#### 4.0µm hole, 2.0µm space

G297/C25 CF-4/2-2C 4µm hole x 2µm space on 200 mesh Cu grid (25) G297/C50 CF-4/2-2C 4µm hole x 2µm space on 200 mesh Cu grid (50) G297/C100 CF-4/2-2C 4µm hole x 2µm space on 200 mesh Cu grid (100)

G296/C25 CF-4/1-4C 4µm hole x 1µm space on 400 mesh Cu grid (25) G296/C50 CF-4/1-4C 4µm hole x 1µm space on 400 mesh Cu grid (50) G296/C100 CF-4/1-4C 4 $\mu$ m hole x 1 $\mu$ m space on 400 mesh Cu grid (100)



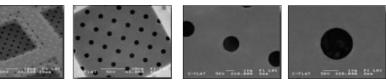
G298/C25 CF-4/2-4C 4µm hole x 2µm space on 400 mesh Cu grid (25) G298/C50 CF-4/2-4C 4µm hole x 2µm space on 400 mesh Cu grid (50) G298/C100 CF-4/2-4C 4µm hole x 2µm space on 400 mesh Cu grid (100)

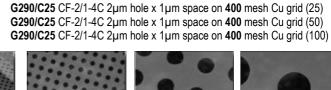
G292/C25 CF-2/2-4C 2µm hole x 2µm space on 400 mesh Cu grid (25) G292/C50 CF-2/2-4C 2µm hole x 2µm space on 400 mesh Cu grid (50) G292/C100 CF-2/2-4C 2µm hole x 2µm space on 400 mesh Cu grid (100)

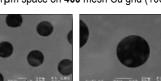
G294/C25 CF-2/2-4C 2µm hole x 4µm space on 400 mesh Cu grid (25)

G294/C50 CF-2/2-4C 2µm hole x 4µm space on 400 mesh Cu grid (50)

G294/C100 CF-2/2-4C 2µm hole x 4µm space on 400 mesh Cu grid (100)







### **Quantifoil® Holey Carbon Films**

QUANTIFOIL® holey carbon films are produced by a semiconductor lithographic process. They are available with different hole sizes, shapes and arrangements. Researchers who would like to try out different types of QUANTIFOIL® holey films in order to find out which one meets their requirements best, can order our MixBox. QUANTIFOIL® R 1/4 may be preferred over R 1.2/1.3 (see below), when an increased tolerance with respect to the position of beam and a larger beam diameter are desired, such as in the case with automated image acquisition. QUANTIFOIL® provide a high percentage of open area in addition to minimising total specimen thickness The thickness of the foil is about 20nm, although only 10 nm of carbon is evaporated onto the plastic. The surface properties of QUANTI-FOIL® holey carbon support film, especially the wetting properties, may have to be adapted according to one's particular requirements. Untreated ageing QUANTIFOIL® tends to be hydrophobic. The foil can be made hydrophilic by glow discharging in residual air or by metal coating. QUANTIFOIL® grids are packaged with their coated sides toward the centre of the grid box.. Holey films with new geometric parameters can be designed. In addition, they can be delivered with coatings other than carbon that can be deposited by vacuum evaporation.

QUANTIFOIL® with circular holes is mainly used in cryo-EM. The roundness of the holes is advantageous for the formation of an ice layer of constant thickness. The hole size that is chosen depends on the magnification used and on whether or not one wishes to include a support film in the image. Assessment of the image guality is easier when foil is included in the picture as the power spectrum of a foil is stronger than that of unsupported ice. For those customers unsure of which Quantifoil® to use please try our MixBox .

> Quantifoil® with Round Holes on Copper, Nickel & Gold Grids 200, 300 & 400 Mesh and in 50 or 100 pack sizes

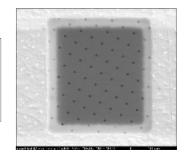
## Quantifoil R 0.6/1

G299/2C/50 Quantifoil 0.6um dia x 1.0um 200 Mesh Cu 50 pack **G299/2C/100** Quantifoil 0.6um dia x 1.0um **200** Mesh *Cu* 100 pack **G299/2N/50** Quantifoil 0.6um dia x 1.0um **200** Mesh *Ni* 50 pack G299/2N/100 Quantifoil 0.6um dia x 1.0um 200 Mesh Ni 100 pack **G299/2G/50** Quantifoil 0.6um dia x 1.0um **200** Mesh *Au* 50 pack G299/2G/100 Quantifoil 0.6um dia x 1.0um 200 Mesh Au 100 pack G299/3G/100 Quantifoil 0.6um dia x 1.0um 300 Mesh Au 100 pck

**G299/3C/50** Quantifoil 0.6um dia x 1.0um **300** Mesh *Cu* 50 pack G299/3C/100 Quantifoil 0.6um dia x 1.0um 300 Mesh Cu 100 pck G299/3N/50 Quantifoil 0.6um dia x 1.0um 300 Mesh Ni 50 pack **G299/3N/100** Quantifoil 0.6um dia x 1.0um **300** Mesh *Ni* 100 pck **G299/3G/50** Quantifoil 0.6um dia x 1.0um **300** Mesh Au 50 pack

**G299/4C/50** Quantifoil 0.6um dia x 1.0um **400** Mesh *Cu* 50 pack G299/4C/100 Quantifoil 0.6um dia x 1.0um 400 Mesh Cu 100 pack G299/4N/50 Quantifoil 0.6um dia x 1.0um 400 Mesh *Ni* 50 pack G299/4N/100 Quantifoil 0.6um dia x 1.0um 400 Mesh Ni 100 pack **G299/4G/50** Quantifoil 0.6um dia x 1.0um **400** Mesh *Au* 50 pack G299/4G/100 Quantifoil 0.6um dia x 1.0um 400 Mesh Au 100 pack

Quantifoil® Holey Carbon Films with **0.6µm holes** separated by 1µm spaces



### Quantifoil R 1.2/1.3

G300/2C/50 Quantifoil 1.2µm dia x 1.3µm 200 Mesh Cu 50 pack G300/2C/100 Quantifoil 1.2µm dia x 1.3µm 200 Mesh Cu 100 pack **G300/2N/50** Quantifoil 1.2µm dia x 1.3µm **200** Mesh *Ni* 50 pack **G300/2N/100** Quantifoil 1.2µm dia x 1.3µm **200** Mesh *Ni* 100 pack **G300/2G/50** Quantifoil 1.2µm dia x 1.3µm **200** Mesh Au 50 pack G300/2G/100 Quantifoil 1.2µm dia x 1.3µm 200 Mesh Au 100 pack G300/3G/100 Quantifoil 1.2µm dia x 1.3µm 300 Mesh Au 100 pack

G300/4C/50 Quantifoil 1.2µm dia x 1.3µm 400 Mesh Cu 50 pack G300/4C/100 Quantifoil 1.2µm dia x 1.3µm 400 Mesh Cu 100 pck G300/4N/50 Quantifoil 1.2µm dia x 1.3µm 400 Mesh Ni 50 pack G300/4N/100 Quantifoil 1.2µm dia x 1.3µm 400 Mesh Ni 100 pck G300/4G/50 Quantifoil 1.2µm dia x 1.3µm 400 Mesh Au 50 pack G300/4G/100 Quantifoil 1.2µm dia x 1.3µm 400 Mesh Au 100 pck **G300/3C/50** Quantifoil 1.2µm dia x 1.3µm **300** Mesh *Cu* 50 pack G300/3C/100 Quantifoil 1.2µm dia x 1.3µm 300 Mesh Cu 100 pck **G300/3N/50** Quantifoil 1.2µm dia x 1.3µm **300** Mesh *Ni* 50 pack G300/3N/100 Quantifoil 1.2µm dia x 1.3µm 300 Mesh Ni 100 pck **G300/3G/50** Quantifoil 1.2µm dia x 1.3µm **300** Mesh Au 50 pack

Quantifoil® Holey Carbon Films with **1.2µm holes** separated by 1.3µm spaces

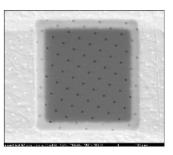


### Quantifoil R 1/4

G301/2C/50Quantifoil 1um dia x 4um 200Mesh Cu 50 packG301/2C/100Quantifoil 1um dia x 4um 200Mesh Cu 100 packG301/2N/50Quantifoil 1um dia x 4um 200Mesh Ni 50 packG301/2N/100Quantifoil 1um dia x 4um 200Mesh Ni 100 packG301/2G/50Quantifoil 1um dia x 4um 200Mesh Au 50 packG301/2G/100Quantifoil 1um dia x 4um 200Mesh Au 50 pack

G301/3C/50 Quantifoil 1um dia x 4um 300 Mesh *Cu* 50 pack G301/3C/100 Quantifoil 1um dia x 4um 300 Mesh *Cu* 100 pack G301/3N/50 Quantifoil 1um dia x 4um 300 Mesh *Ni* 50 pack G301/3N/100 Quantifoil 1um dia x 4um 300 Mesh *Ni* 100 pack G301/3G/50 Quantifoil 1um dia x 4um 300 Mesh *Au* 50 pack G301/3G/100 Quantifoil 1um dia x 4um 300 Mesh *Au* 100 pack

G301/4C/50 Quantifoil 1um dia x 4um 400 Mesh *Cu* 50 pack G301/4C/100 Quantifoil 1um dia x 4um 400 Mesh *Cu* 100 pack G301/4N/50 Quantifoil 1um dia x 4um 400 Mesh *Ni* 50 pack G301/4N/100 Quantifoil 1um dia x 4um 400 Mesh *Ni* 100 pack G301/4G/50 Quantifoil 1um dia x 4um 400 Mesh *Au* 50 pack G301/4G/100 Quantifoil 1um dia x 4um 400 Mesh *Au* 100 pack Quantifoil® Holey Carbon Films with 1µm holes separated by 4µm spaces

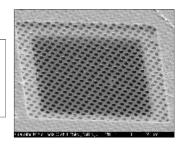


#### Quantifoil R 2/1

G310/2C/50 Quantifoil 2µm dia x 1µm 200 mesh *Cu* 50 pack G310/2C/100 Quantifoil 2µm dia x 1µm 200 mesh *Cu* 100 pack G310/2N/50 Quantifoil 2µm dia x 1µm 200 mesh *Ni* 50 pack G310/2N/100 Quantifoil 2µm dia x 1µm 200 mesh *Ni* 100 pack G310/2G/50 Quantifoil 2µm dia x 1µm 200 mesh *Au* 50 pack G310/2G/100 Quantifoil 2µm dia x 1µm 200 mesh *Au* 100 pack

G310/4C/50 Quantifoil 2µm dia x 1µm 400 mesh *Cu* 50 pack G310/4C/100 Quantifoil 2µm dia x 1µm 400 mesh *Cu* 100 pack G310/4N/50 Quantifoil 2µm dia x 1µm 400 mesh *Ni* 50 pack G310/4N/100 Quantifoil 2µm dia x 1µm 400 mesh *Ni* 100 pack G310/4G/50 Quantifoil 2µm dia x 1µm 400 mesh *Au* 50 pack G310/4G/100 Quantifoil 2µm dia x 1µm 400 mesh *Au* 100 pack G310/3C/50 Quantifoil 2µm dia x 1µm 300 mesh *Cu* 50 pack G310/3C/100 Quantifoil 2µm dia x 1µm 300 mesh *Cu* 100 pack G310/3N/50 Quantifoil 2µm dia x 1µm 300 mesh *Ni* 50 pack G310/3N/100 Quantifoil 2µm dia x 1µm 300 mesh *Ni* 100 pack G310/3G/50 Quantifoil 2µm dia x 1µm 300 mesh *Au* 50 pack G310/3G/100 Quantifoil 2µm dia x 1µm 300 mesh *Au* 100 pack

Quantifoil® Holey Carbon Films with 2µm holes separated by 1µm spaces



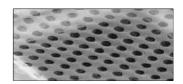
### Quantifoil R 2/2

**G302/2C/50** Quantifoil 2um dia x 2um **200** Mesh *Cu* 50 pack **G302/2C/100** Quantifoil 2um dia x 2µm **200** Mesh *Cu* 100 pack **G302/2N/50** Quantifoil 2um dia x 2um **200** Mesh *Ni* 50 pack **G302/2N/100** Quantifoil 2um dia x 2um **200** Mesh *Ni* 100 pack **G302/2G/50** Quantifoil 2um dia x 2um **200** Mesh *Au* 50 pack **G302/2G/100** Quantifoil 2um dia x 2um **200** Mesh *Au* 50 pack

G302/4C/50Quantifoil 2um dia x 2um 400 Mesh Cu 50 packG302/4C/100Quantifoil 2um dia x 2um 400 Mesh Cu 100 packG302/4N/50Quantifoil 2um dia x 2um 400 Mesh Ni 50 packG302/4N/100Quantifoil 2um dia x 2um 400 Mesh Ni 100 packG302/4G/50Quantifoil 2um dia x 2um 400 Mesh Au 50 packG302/4G/100Quantifoil 2um dia x 2um 400 Mesh Au 50 packG302/4G/100Quantifoil 2um dia x 2um 400 Mesh Au 100 pck

G302/3C/50Quantifoil 2um dia x 2um 300 Mesh Cu 50 packG302/3C/100Quantifoil 2um dia x 2um 300 Mesh Cu 100 packG302/3N/50Quantifoil 2um dia x 2um 300 Mesh Ni 50 packG302/3N/100Quantifoil 2um dia x 2um 300 Mesh Ni 100 packG302/3G/50Quantifoil 2um dia x 2um 300 Mesh Au 50 packG302/3G/100Quantifoil 2um dia x 2um 300 Mesh Au 50 pack

Quantifoil® Holey Carbon Films with 2µm holes separated by 2µm spaces



#### Please ask for our data sheet

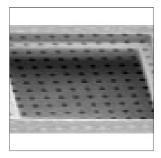
## **Grids & Specimen Supports**

#### Quantifoil R 2/4

G303/2C/50 Quantifoil 2um dia x 4um 200 Mesh *Cu* 50 pack G303/2C/100 Quantifoil 2um dia x 4um 200 Mesh *Cu* 100 pack G303/2N/50 Quantifoil 2um dia x 4um 200 Mesh *Ni* 50 pack G303/2N/100 Quantifoil 2um dia x 4um 200 Mesh *Ni* 100 pack G303/2G/50 Quantifoil 2um dia x 4um 200 Mesh *Au* 50 pack G303/2G/100 Quantifoil 2um dia x 4um 200 Mesh *Au* 100 pack G303/3C/50 Quantifoil 2um dia x 4um 300 Mesh *Cu* 50 pack G303/3C/100 Quantifoil 2um dia x 4um 300 Mesh *Cu* 100 pack G303/3N/50 Quantifoil 2um dia x 4um 300 Mesh *Ni* 50 pack G303/3N/100 Quantifoil 2um dia x 4um 300 Mesh *Ni* 100 pack G303/3G/50 Quantifoil 2um dia x 4um 300 Mesh *Au* 50 pack G303/3G/100 Quantifoil 2um dia x 4um 300 Mesh *Au* 100 pack

G303/4C/50Quantifoil 2um dia x 4um 400Mesh Cu 50 packG303/4C/100Quantifoil 2um dia x 4um 400Mesh Cu 100 packG303/4N/50Quantifoil 2um dia x 4um 400Mesh Ni 50 packG303/4N/100Quantifoil 2um dia x 4um 400Mesh Ni 100 packG303/4G/50Quantifoil 2um dia x 4um 400Mesh Au 50 packG303/4G/100Quantifoil 2um dia x 4um 400Mesh Au 50 pack

Quantifoil® Holey Carbon Films with 2µm holes separated by 4µm spaces



#### Quantifoil R 3.5/1

G304/2C/50 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 200 Mesh *Cu* 50 pack G304/2C/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 200 Mesh *Cu* 100 pack G304/2N/50 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 200 Mesh *Ni* 50 pack G304/2N/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 200 Mesh *Ni* 100 pack G304/2G/50 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 200 Mesh *Au* 50 pack G304/2G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 200 Mesh *Au* 50 pack G304/2G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 200 Mesh *Au* 100 pack

G304/4C/50 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Cu* 50 pack G304/4C/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Cu* 100 pck G304/4N/50 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Ni* 50 pack G304/4N/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Ni* 100 pck G304/4G/50 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 50 pack G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 50 pack G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 50 pack G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck G304/4G/100 Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m 400 Mesh *Au* 100 pck Mesh Au 10

**G304/3C/50** Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m **300** Mesh *Cu* 50 pack **G304/3C/100** Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m **300** Mesh *Cu* 100 pck **G304/3N/50** Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m **300** Mesh *Ni* 50 pack **G304/3N/100** Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m **300** Mesh *Ni* 100 pck **G304/3G/50** Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m **300** Mesh *Au* 50 pack **G304/3G/100** Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m **300** Mesh *Au* 50 pack **G304/3G/100** Quantifoil 3.5 $\mu$ m dia x 1 $\mu$ m **300** Mesh *Au* 50 pack

Quantifoil® Holey Carbon Films with 3.5µm holes separated by 1µm spaces

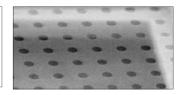
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#### Quantifoil R 5/20

G305/2C/50Quantifoil  $5\mu$ m dia x  $20\mu$ m 200 Mesh Cu 50 packG305/2C/100Quantifoil  $5\mu$ m dia x  $20\mu$ m 200 Mesh Cu 100 packG305/2N/50Quantifoil  $5\mu$ m dia x  $20\mu$ m 200 Mesh Ni 50 packG305/2N/100Quantifoil  $5\mu$ m dia x  $20\mu$ m 200 Mesh Ni 100 packG305/2G/50Quantifoil  $5\mu$ m dia x  $20\mu$ m 200 Mesh Au 50 packG305/2G/100Quantifoil  $5\mu$ m dia x  $20\mu$ m 200 Mesh Au 50 packG305/2G/100Quantifoil  $5\mu$ m dia x  $20\mu$ m 200 Mesh Au 50 pack

**G305/4C/50** Quantifoil 5µm dia x 20µm **400** Mesh *Cu* 50 pack **G305/4C/100** Quantifoil 5µm dia x 20µm **400** Mesh *Cu* 100 pck **G305/4N/50** Quantifoil 5µm dia x 20µm **400** Mesh *Ni* 50 pack **G305/4N/100** Quantifoil 5µm dia x 20µm **400** Mesh *Ni* 100 pck **G305/4G/50** Quantifoil 5µm dia x 20µm **400** Mesh *Au* 50 pack **G305/4G/100** Quantifoil 5µm dia x 20µm **400** Mesh *Au* 50 pack **G305/3C/50** Quantifoil 5µm dia x 20µm **300** Mesh *Cu* 50 pack **G305/3C/100** Quantifoil 5µm dia x 20µm **300** Mesh *Cu* 100 pck **G305/3N/50** Quantifoil 5µm dia x 20µm **300** Mesh *Ni* 50 pack **G305/3N/100** Quantifoil 5µm dia x 20µm **300** Mesh *Ni* 100 pck **G305/3G/50** Quantifoil 5µm dia x 20µm **300** Mesh *Au* 50 pack **G305/3G/100** Quantifoil 5µm dia x 20µm **300** Mesh *Au* 50 pack

Quantifoil® Holey Carbon Films with 5µm holes separated by 20µm spaces





### Quantifoil Multi A

G306/2C/50 Quantifoil Multi A 200 Mesh *Cu* 50 pack G306/2C/100 Quantifoil Multi A 200 Mesh *Cu* 100 pack G306/2N/50 Quantifoil Multi A 200 Mesh *Ni* 50 pack G306/2N/100 Quantifoil Multi A 200 Mesh *Ni* 100 pack

G306/4C/50Quantifoil Multi A 400 Mesh Cu 50 packG306/4C/100Quantifoil Multi A 400 Mesh Cu 100 pckG306/4N/50Quantifoil Multi A 400 Mesh Ni 50 packG306/4N/100Quantifoil Multi A 400 Mesh Ni 100 pack

G306/3C/50 Quantifoil Multi A 300 Mesh *Cu* 50 pack G306/3C/100 Quantifoil Multi A 300 Mesh *Cu* 100 pck G306/3N/50 Quantifoil Multi A 300 Mesh *Ni* 50 pack G306/3N/100 Quantifoil Multi A 300 Mesh *Ni* 100 pack

Quantifoil® Holey Carbon Films with different hole sizes and patterns

### **Quantifoil Hex15**

G307/Hex15/C/50Quantifoil hexagonal mesh on 0.5 x 2mm slot grids Cu 50 packG307/Hex15/C/100Quantifoil hexagonal mesh on 0.5 x 2mm slot grids Cu 100 pack

Quantifoil® Hexagonal on slot grid 0.5 x 2mm For section support giving greatest open area Hole size 26µm Bar width 15µm repeat distance 41µm

#### Quantifoil® with Square Holes on copper, nickel and gold grids

### Quantifoil S 7/2

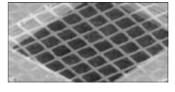
**G308/C/S72/50** Quantifoil S 7/2 square 7 x 7 $\mu$ m holes *Cu* 50 pack **G308/C/S72/100** Quantifoil S 7/2 square 7 x 7 $\mu$ m holes *Cu* 100 pack **G308/N/S72/50** Quantifoil S 7/2 square 7 x 7 $\mu$ m holes *Ni* 50 pack **G308/N/S72/100** Quantifoil S 7/2 square 7 x 7 $\mu$ m holes *Ni* 100 pack **G308/G/S72/50** Quantifoil S 7/2 square 7 x 7 $\mu$ m holes *Au* 50 pack **G308/G/S72/100** Quantifoil S 7/2 square 7 x 7 $\mu$ m holes *Au* 50 pack **G308/G/S72/100** Quantifoil S 7/2 square 7 x 7 $\mu$ m holes *Au* 100 pck

> Quantifoil® with **square holes** and **narrow bars** can be used in TEM to support a thin carbon film which by itself is too fragile to span a grid square. Alternatively, this holey film can directly support an object that is larger than the holes.

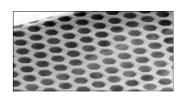
#### **Quantifoil® MixBox**

The MixBox contains 5 pieces each of the following on 300 mesh copper grids

G309	Quantifoil® MixBox	



R 1.2/1.3 R 2/1 R 3.5/1 S 7/2 Multi A



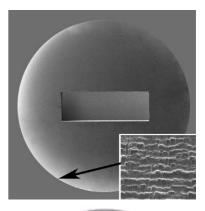
## **Grids & Specimen Supports**

### Silicon Nitride (Si $_{3}N_{4}$ ) Thin Film Windows for Microscopy

TAAB introduces a new generation of Silicon Nitride Support Films for EM imaging and analysis from Ted Pella. These resilient, ultra-smooth low stress inorganic silicon nitride support films have been developed as an addition to our available range of TEM support films to enable specific nanotechnology and molecular biology research. Each window has an EasyGrip<sup>™</sup> edge.

Silicon nitride support films have the great advantages of being chemically and mechanically robust and are able to withstand temperature changes up to 1000°C. They are extremely stable and suitable to conduct a variety of nanotechnology experiments with particles or cells mounted directly on the support films. They have greatly improved handling capabilities with EasyGrip<sup>™</sup> edges. The frame is manufactured as a 3mm x 200µm silicon disc and will fit perfectly in standard TEM holders.

Each Silicon Nitride Support Film is manufactured with a 3mm diameter structure compatible with TEM grids and is completely free from debris particles. The purpose designed packaging and clean room assembly and packaging keeps the support films free from artefacts and contamination. The mechanical and chemical stability allow for cleaning of the silicon nitride support films with chemicals (solvents, acids and bases), glow discharge and plasma cleaning. *Ultrasonic cleaning is not recommended* as it may shatter the silicon nitride membrane.





#### **Examples of Application Fields**

EasyGrip™ Edge

The Silicon Nitride Support Films are indispensable tools for virtually all fields of nanotechnology research. They enable direct deposition and in-situ observations of dynamic reactions over a wide temperature range. Applications fields include, but are not limited to:

- · Cell biology: attached cells can be grown in their environment on the support film and subsequently analysed
- · Analysis of colloids, aerosols, nanoparticles
- Self-assembled mono-layers
- Polymer research
- Thin film research (directly deposited on the silicon nitride support film)
- Materials science
- Properties of nano-structures for semiconductor devices
- Semiconductor; characterisation of thin films

#### •

#### Catalyst development

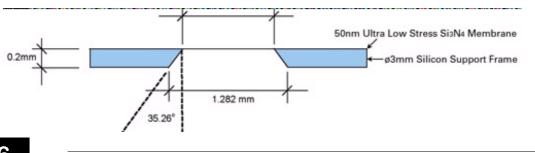
These superior Silicon nitride support films are made by state-of-the-art semiconductor and MEMS fabrication techniques using resilient, low-stress inorganic silicon nitride thin films supported by a sturdy silicon frame. The thin silicon nitride film is grown on a 200 $\mu$ m thick silicon wafer to the desired membrane thickness of 50nm. The specimen viewing area is created by etching away a window in the silicon wafer substrate underneath the Si<sub>3</sub>N<sub>4</sub> membrane, leaving a perfectly smooth, resilient and chemically robust silicon nitride film. The membrane is not supported in the window area, enabling large viewing areas without any disturbing bars. A new addition is Hydrophobic and Hydrophilic Substrates for Nanotechnology and Biotechnology applications. The 50nm membranes have been Atomic Layer-Deposited (ALD) modified to created these surfaces.

#### Window sizes and shape

The following window sizes are available with 8, 15, 35 or 50nm thin support on 3mm Ø frame :

0.25 x 0.25mm, 0.5 x 5mm, 0.75 x 0.75mm, 1 x 1 mm. and 1.5 x 0.5mm. There are multiple window versions with 9 windows of 0.1 x 0.1mm in a 3x3 array or 2 windows of 0.1 x 1.5mm.

Due to the structure of the silicon and the etching process the window in the silicon substrate is etched with a 35° angle, leaving a much larger opening than the membrane window at the back of the frame.



#### Effects of tilt

Due to the 35° etching angle the Si<sub>3</sub>N<sub>4</sub> support films on the frames can be tilted to 35° for unobstructed viewing, even if the specimen is close to the edge of the membrane. For higher tilting angles, the specimen needs to be in the centre of the membrane. To allow for the highest possible tilt angle a window size of 1.5 x 0.5mm has been made available which allows for tilting angles up to 70° with a viewable area of 40%. Maximum tilt angle with a specimen in the centre is 75°.

Surface Roughness: The RMS (Rg) is 0.65 +/- 0.06nm which gives a mean roughness (Ra) of 0.45 +/- 0.02nm.

Packaging: The Silicon Nitride Support Films are packaged under cleanroom conditions in a TEM Grid Storage Box. Each box holds 10 support films.

Single or multiple windows         9 each 0.1 x 0.1 mm apertures         2 each 0.1 x 1.5mm Apertures         Ultra thin dom           Utra-thin Membrane Versions 25 Apertures - 200µm Frame Thickness         SXX         Silicon Nitride Support Film, 8mm, 60 x 60µm Apertures (25) on 0.5x0.5mm window         pack of 10           15mm embrane thickness - 200µm Frame Thickness         SXX         Silicon Nitride Support Film, 15mm with 0.25 x 0.25mm window         pack of 10           35mm embrane thickness - 200µm frame thickness         SXXX         Silicon Nitride Support Film, 50mm with 0.25 x 0.25mm window         pack of 10           35xxx         Silicon Nitride Support Film, 50mm with 0.25 x 0.25mm window         pack of 10           SXXX         Silicon Nitride Support Film, 50mm with 0.25 x 0.25mm window         pack of 10           SXXX         Silicon Nitride Support Film, 50mm with 0.25 x 0.25mm window         pack of 10           SXXX         Silicon Nitride Support Film, 50mm with 0.25 x 0.25mm window         pack of 10           SXXX         Silicon Nitride Support Film, 50mm with 0.25 x 0.75mm window         pack of 10           SXXX         Silicon Nitride Support Film, 50mm with 0.5 x 1.5mm window         pack of 10           SXXX         Silicon Nitride Support Film, 50mm with 0.5 x 1.5mm window         pack of 10           SXXX         Silicon Nitride Support Film, 50mm with 0.5 x 0.5mm window         pack of 10					
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SXXX Silicon Nitride Support Film, 50nm on 50µm thick frame with 0.25 x 0.25mm window pack of 10	SXXX SXXX/1 SXXX SXXX/1 SXXX SXXX/1 SXXX SXXX	Silicon Nitride Support Film, Silicon Nitride Support Film,	200nm with 0.25 x 0.25mm window 200nm with 0.25 x 0.25mm window 200nm with 0.5 x 0.5mm window 200nm with 0.5 x 0.5mm window 200nm with 0.75 x 07.5mm window 200nm with 0.75 x 07.5mm window 200nm with 1.0 x 1.0mm window 200nm with 1.0 x 1.5mm window 200nm with 0.5 x 1.5mm window 200nm with 0.5 x 1.5mm window 200nm with 0.1 x 1.5mm window		pack of 100 pack of 10 pack of 100 pack of 10 pack of 100 pack of 100 pack of 100 pack of 100 pack of 100 pack of 100 pack of 10
<b>CYYY</b> Silican Nitrida Support Film 50pm on 50um thick frame with 2 each 0.1 v.1 5mm windows nearly of 10		Silicon Nitride Support Film,	50nm on 50µm thick frame with 0.		pack of 10

SXXX Silicon Nitride Support Film, 50nm on 50µm thick frame with 2 each 0.1 x 1.5mm windows pack of 10 pack of 10

SXXX Silicon Nitride Support Film, 50nm on 50µm thick frame with 9 each 0.1 x 0.1mm windows

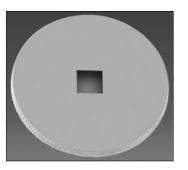
## **Grids & Specimen Supports**

## Silicon Nitride Assortment Pack

With various membrane thicknesses and sizes. The Assortment Pack is the ideal way to determine which membrane thickness or size of silicon nitride or silicon dioxide is the optimum product for your application. The assortment pack includes the following thickness and window sizes on **200um thick silicon frames**:

Position in grid box	Unit no.	Membrane Type
1A	1	Si3N4 15nm membrane with 0.25 x 0.25mm window
1B	1	Si3N4 15nm membrane with 0.25 x 0.25mm window
1C	1	Si3N4 50nm membrane with 0.25 x 0.25mm window
1D	1	Si3N4 50nm membrane with 9 each 0.1 x 0.1mm windows
1E	1	Si3N4 50nm membrane with 0.5 x 0.5mm window
2A	1	Si3N4 50nm membrane with 0.75 x 0.75mm window
2B	1	Si3N4 200nm membrane with 0.25 x 0.25mm window
2C	1	Si3N4 200nm membrane with 0.5 x 0.5mm window
2D	1	SiO2 40nm membrane with 0.5 x 0.5mm window
2E	1	Holey Si3N4 200nm membrane with 2.5µm holes with 0.5x0.5mm window

**SXXX** Silicon nitride assortment pack (10 different membranes)



#### Hydrophilic and Hydrophobic $Si_3N_4$ Membrane Surfaces

15nm, 50nm and 200nm Silicon Nitride membranes are Atomic Layer-Deposited (ALD) modified to change their properties. Depending on the process used both Hydrophobic and Hydrophilic substrates have been created with the following advantages:

- Choice between low and high surface energies
- Smooth and conformal substrates
- Enhanced wetting and biocompatibility (hydrophilic)
- Removes need for plasma treatment of surface prior to cell growth
- Hydrophobic coating offers novel platform for deposition and growth of

Both coatings are available on 50nm and 200nm Silicon Nitride Membranes with a 0.5 x 0.5mm window and 15nm Si<sub>3</sub>N<sub>4</sub> membrane with 9 each 0.1 x 0.1nm windows on a 200µm silicon frame with a diameter of 3mm, compatible with all standard TEM grid holders. Both sides of the membrane and frame are coated. We advise handling the discs by gripping at the edge.

#### Specifications

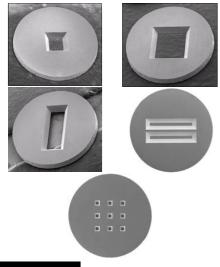
Hydrophilic: 2.5nm atomic layer-deposited hydroxylated alumina on 15, 50 and 200nm ultra - low-stress silicon nitride membrane Hydrophobic: 2.5nm atomic layer-deposited alumina and fluoro-methyl-silane on 15, 50 and 200nm ultra-low-stress silicon nitride membrane

**SXXX** Hydrophilic 15nm Silicon Nitride Membrane, 9 each 0.1 x 0.1mm windows pack of 10 **SXXX** Hydrophilic 50nm Silicon Nitride Membrane 0.5 x 0.5mm window pack of 10 **SXXX** Hydrophilic 200nm Silicon Nitride Membrane, 0.5x0.5mm window pack of 10

SXXX Hydrophobic 15nm Silicon Nitride Membrane 9 each 0.1 x 0.1mm windows pack of 10

S435 Hydrophobic 50nm Silicon Nitride Membrane 0.5 x 0.5mm window pack of 10

SXXX Hydrophobic 200nm Silicon Nitride Membrane, 0.5 x 0.5mm window pack of 10



#### Silicon Nitride Aperture Discs - No Film

These Silicon Nitride Aperture Discs are 3mm disc type frames with a thickness of  $200 \mu m$  and square or rectangular apertures. They have found a variety of applications:

- Support frame to attach TEM lamellas made with FIB
- Support frame for thin films, foils, wires and fibres
- Mask for thin film research (deposition mask)

SXXX	Silicon nitride aperture disc.(no film) 0.25 x 0.25mm	pack 10
SXXX	Silicon nitride aperture disc (no film) 0.5 x 0.5mm	pack 10
SXXX	Silicon nitride aperture disc (no film) 0.75 x 0.75mm	pack 10
SXXX	Silicon nitride aperture disc (no film) 1.0 x 1.0mm	pack 10
SXXX	Silicon nitride aperture disc (no film) 0.5 x 1.5mm	pack 10
SXXX	Si <sub>3</sub> N <sub>4</sub> aperture disc (no film) with two 0.1 x 1.5mm apertures	pack of 10
SXXX	$Si_3N_4$ aperture disc (no film), with nine 0.1 x 0.1mm apertures	pack of 10

#### Silicon Nitride 3mm Blank Discs

These 3mm Ø silicon discs have an ultra-flat (Ra 0.45  $\pm$  0.2nm) 50nm ultra-low-stress Silicon Nitride layer on both sides. Also available with a hydrophilic or hydrophobic surface coating or just as a silicon disc. The discs are made with the same state-of-the-art manufacturing techniques as our other Silicon Nitride Support Films. The disk are perfectly round and have the Easygrip<sup>TM</sup> edge for easy handling. Clean surface, no broken edges and free of debris often associated with other manufacturing processes. The ultra-low-stress film is nonstoichiometric and closer to SiN than Si3N4. They can be used for a number of applications:

Specimen mounts for SEM and FESEM applications Specimen discs for AFM applications which need a Si<sub>3</sub>N<sub>4</sub> background

SXXX	Silicon nitride 3mm Ø blank discs	pack of 10
SXXX	Silicon nitride coated 3mm Ø discs with hydrophilic coating	pack of 10
SXXX	Silicon nitride coated 3mm Ø discs with hydrophobic coating	pack of 10
SXXX	Silicon discs 3mm Ø no coating	pack of 10

Holey Silicon Nitride Support Films

